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(19) **United States**(12) **Patent Application Publication** (10) **Pub. No.: US 2005/0139824 A1**
Park (43) **Pub. Date: Jun. 30, 2005**(54) **DUAL PANEL TYPE ORGANIC
ELECTROLUMINESCENT DEVICE AND
METHOD OF FABRICATING THE SAME**(52) **U.S. Cl. 257/40**(75) **Inventor: Jae-Yong Park, Gyeonggi-do (KR)**(57) **ABSTRACT**

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WASHINGTON, DC 20004 (US)**(73) **Assignee: LG.Philips LCD Co., Ltd.**(21) **Appl. No.: 11/017,110**(22) **Filed: Dec. 21, 2004**(30) **Foreign Application Priority Data**

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An organic electroluminescent device includes first and second substrates facing each other and spaced apart from each other; a gate line on an inner surface of the first substrate; a data line and a power line crossing the gate line and spaced apart from each other; a switching thin film transistor connected to the gate line and the data line; a driving thin film transistor connected to the switching thin film transistor and the power line, the driving thin film transistor including a channel region having a ring shape; an electric connection pattern connected to the driving thin film transistor, the connection pattern being disposed over the driving thin film transistor; and an organic electroluminescent diode on an inner surface of the second substrate, the organic electroluminescent diode being connected to the electric connection pattern.

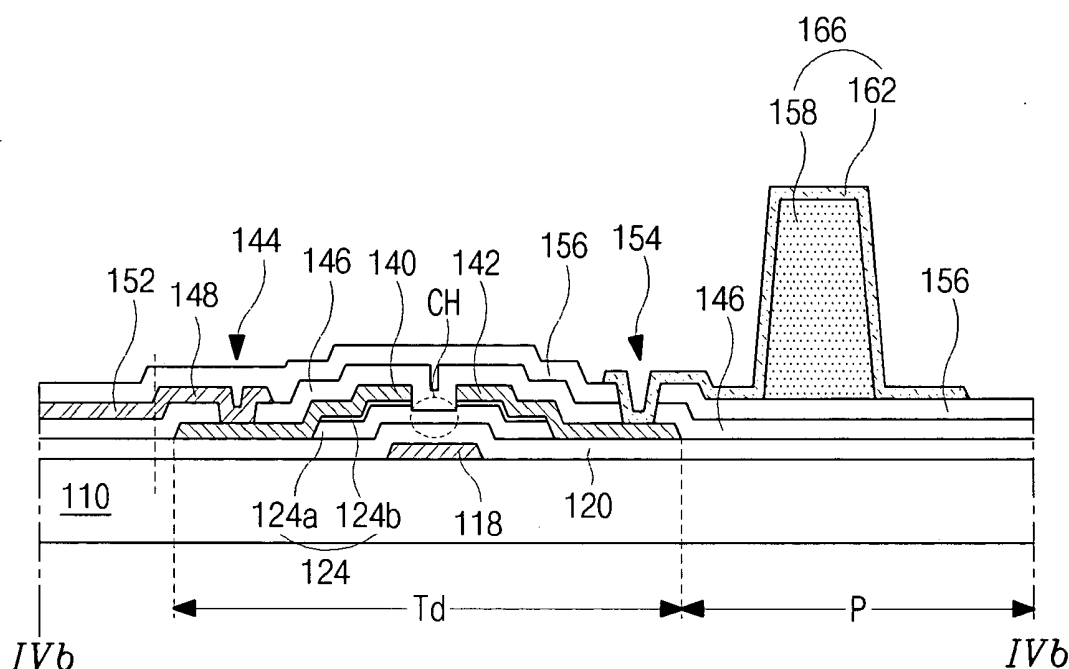


FIG. 1
Related Art

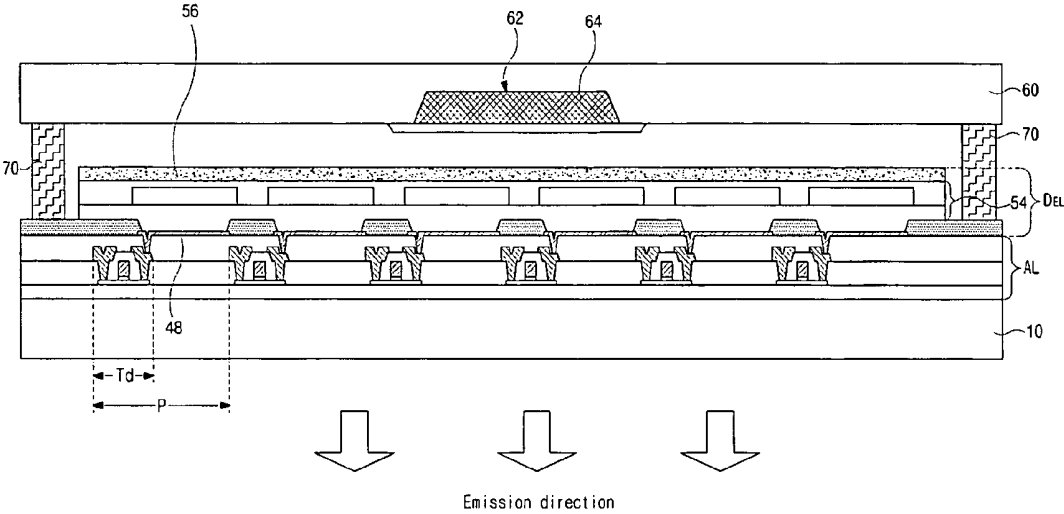


FIG. 2B
Related Art

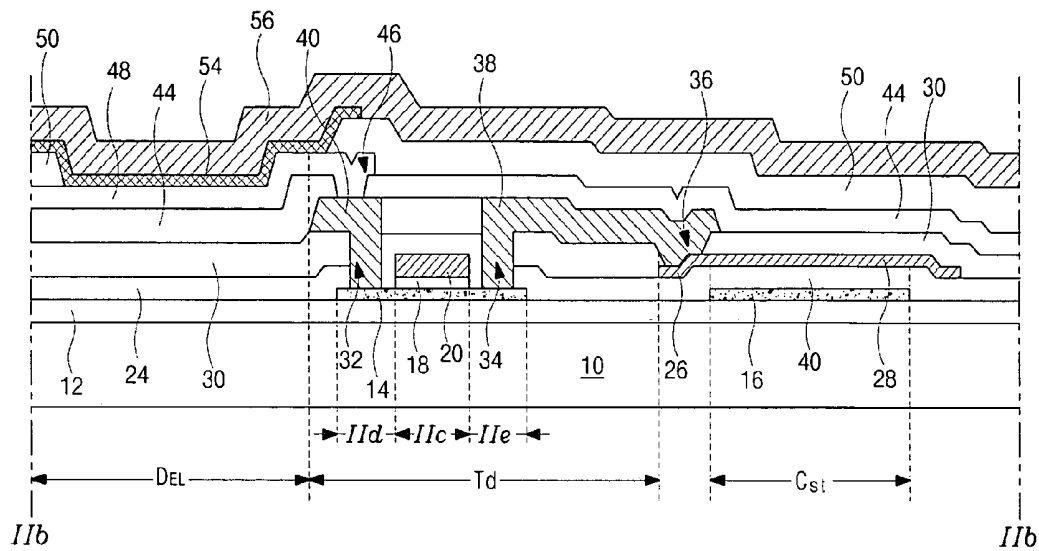


FIG. 3

Emission direction

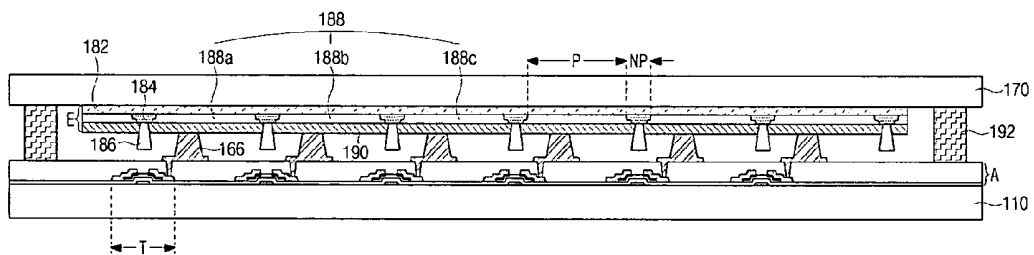
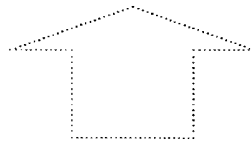


FIG. 4B

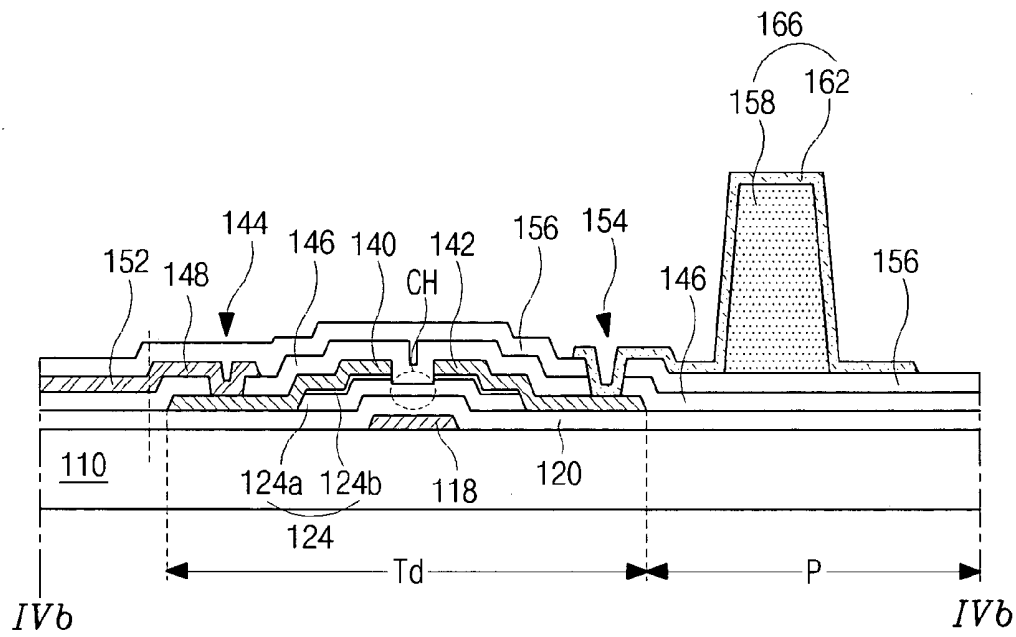


FIG. 5A

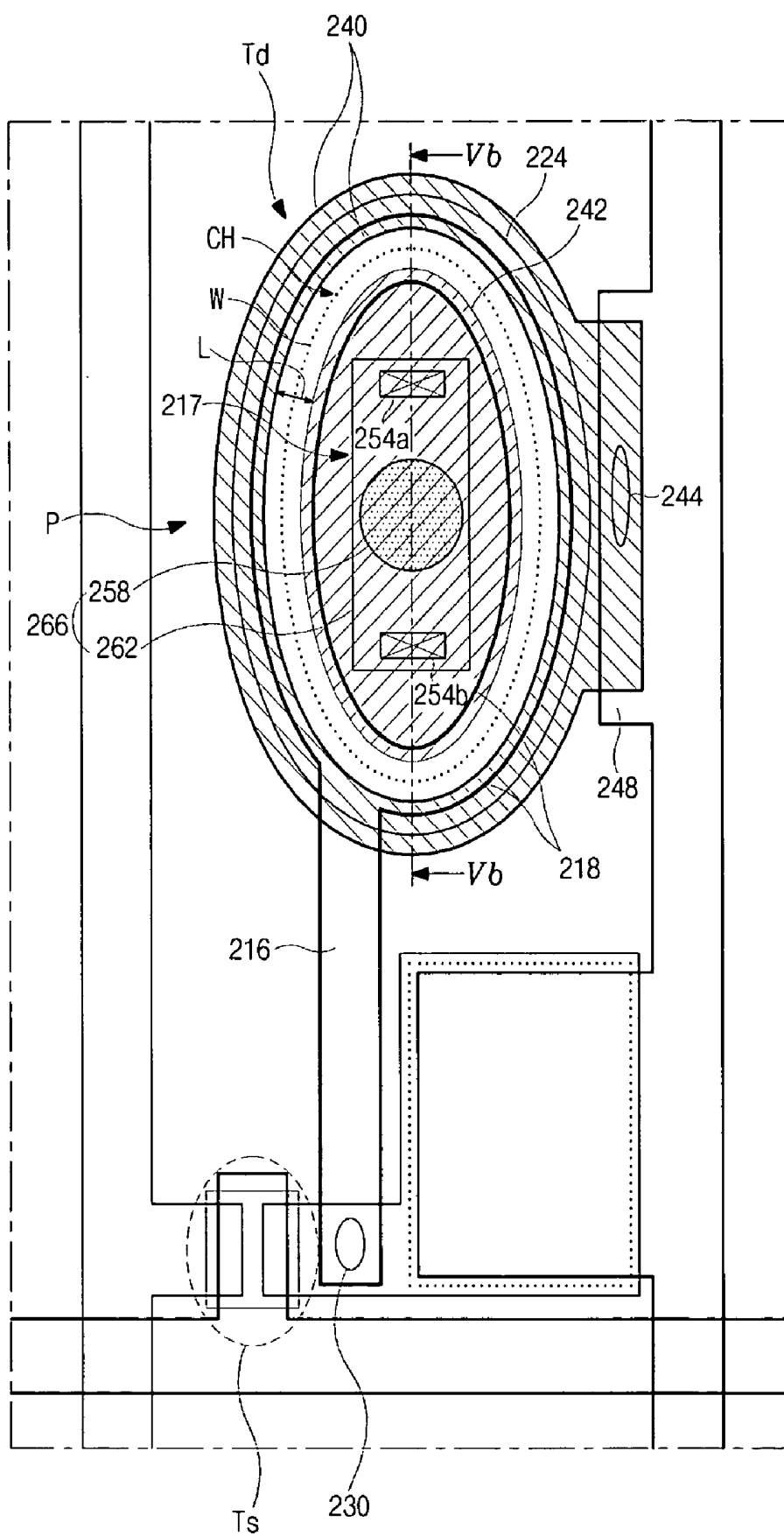


FIG. 5B

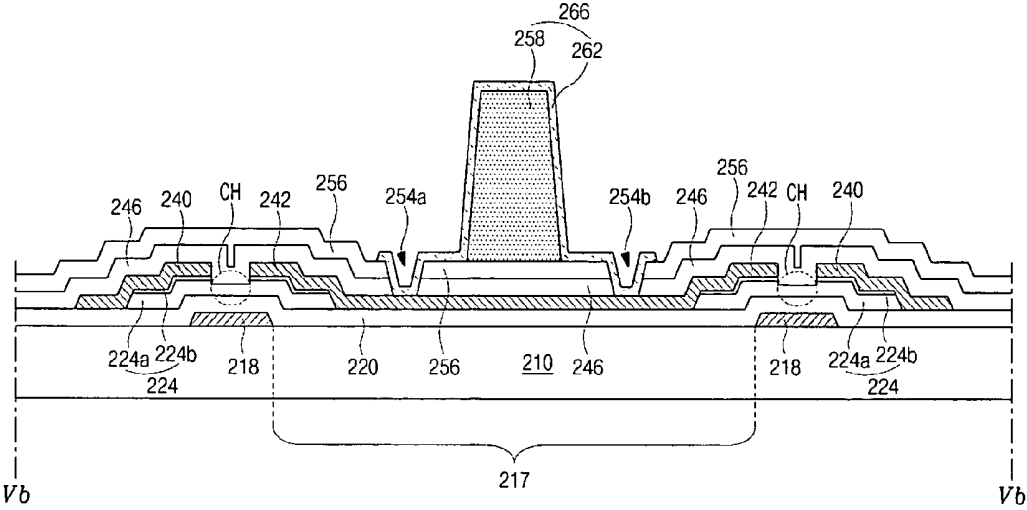


FIG. 6A

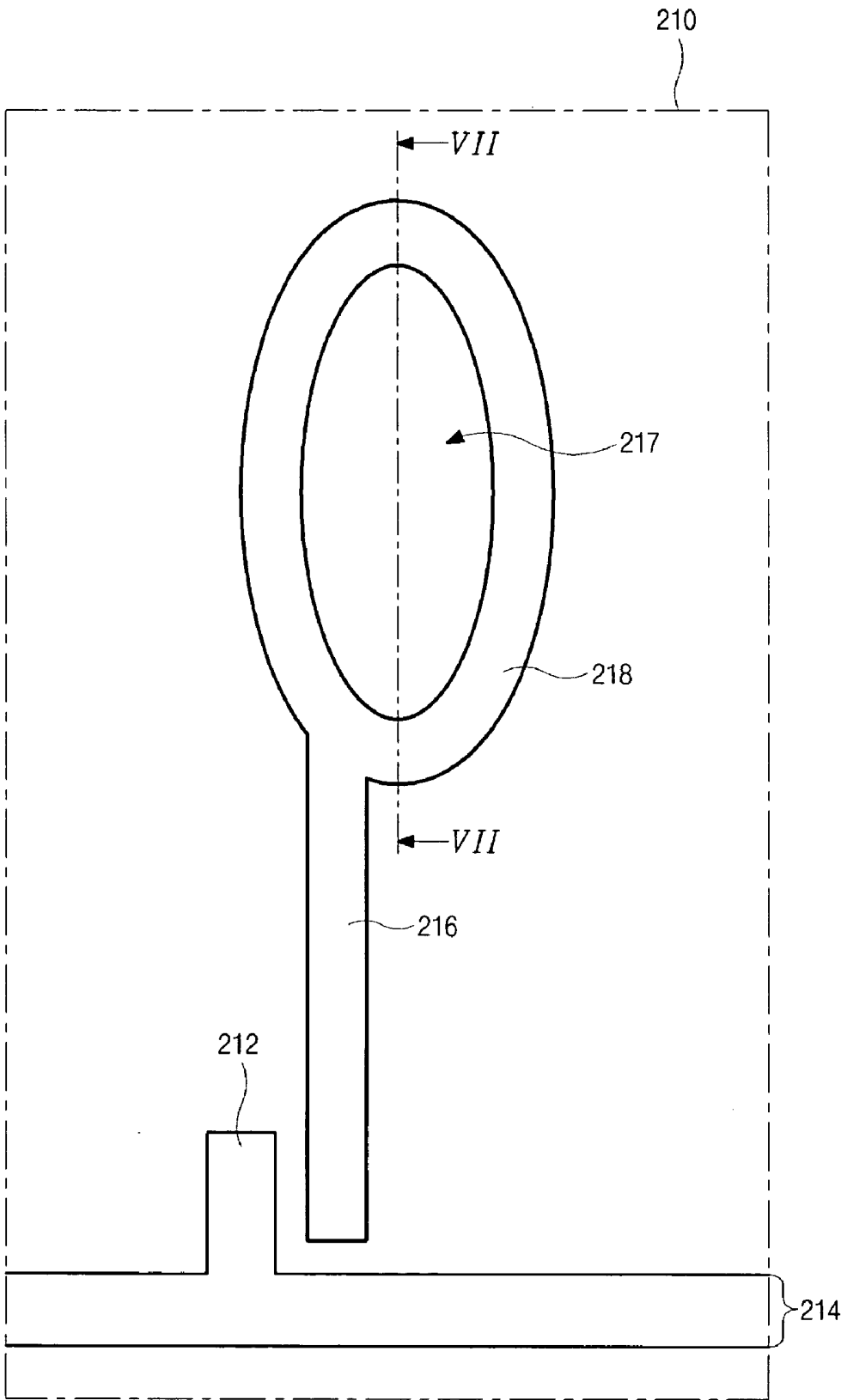


FIG. 6B

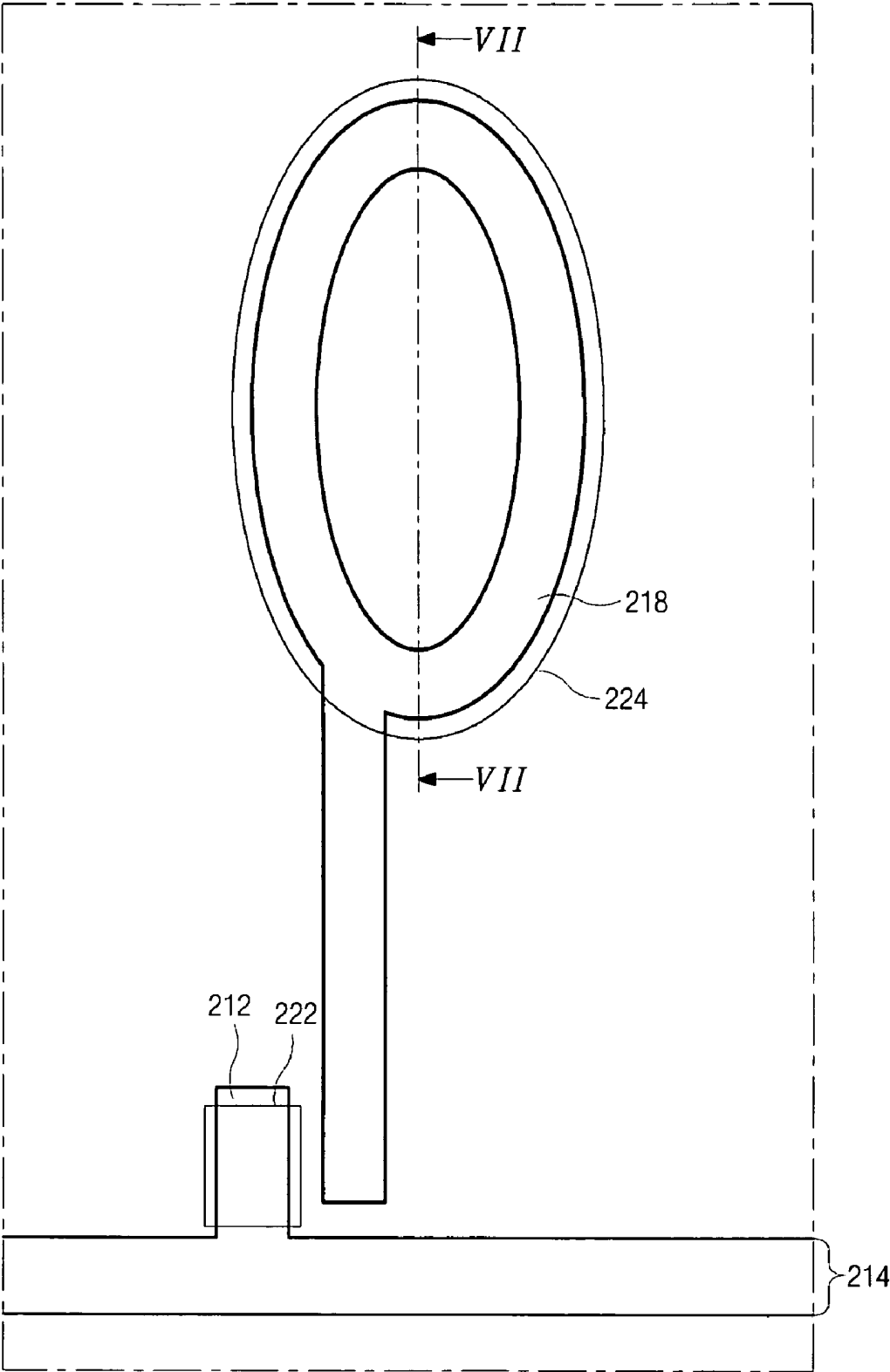


FIG. 6C

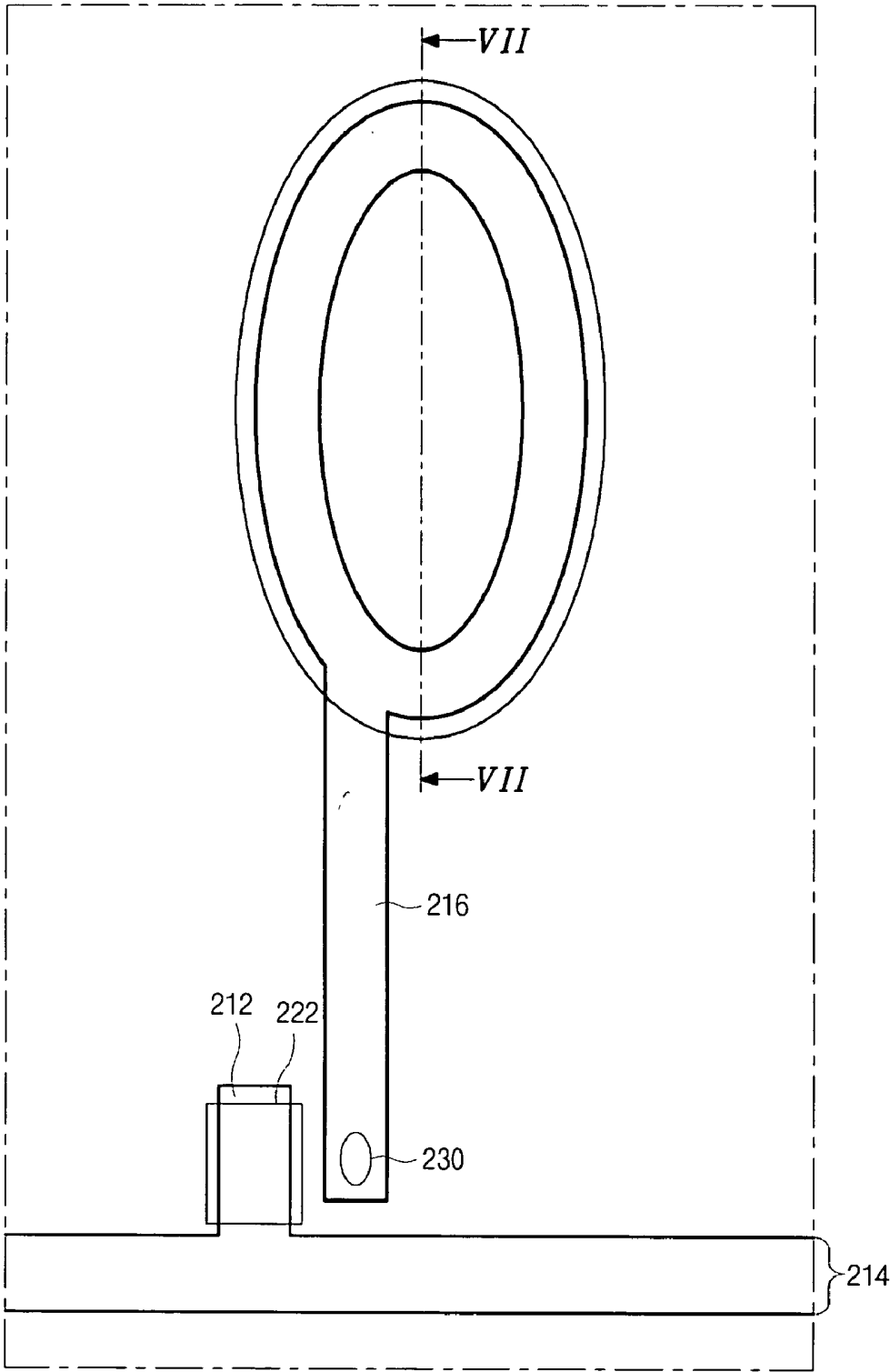


FIG. 6D

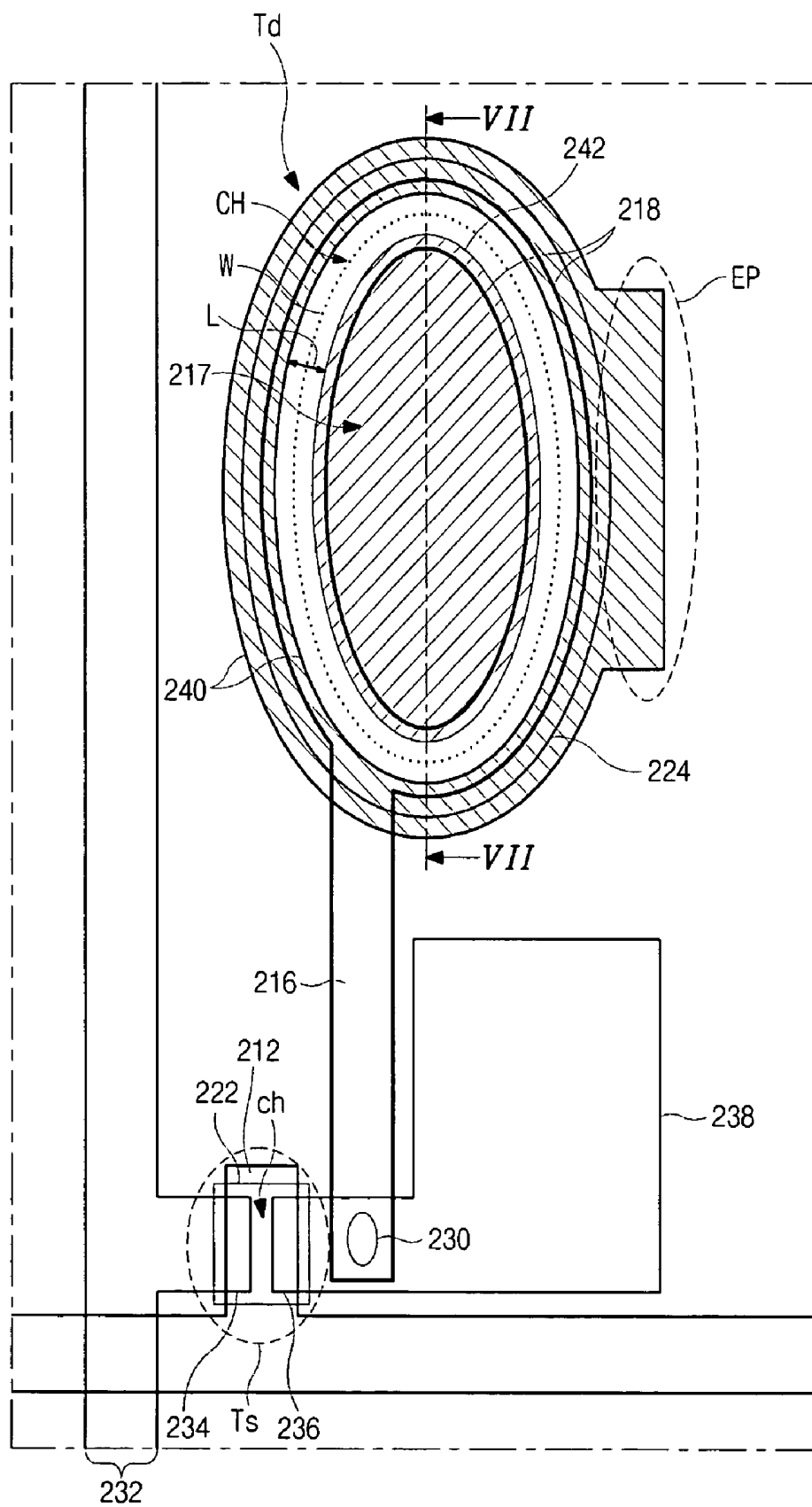


FIG. 6E

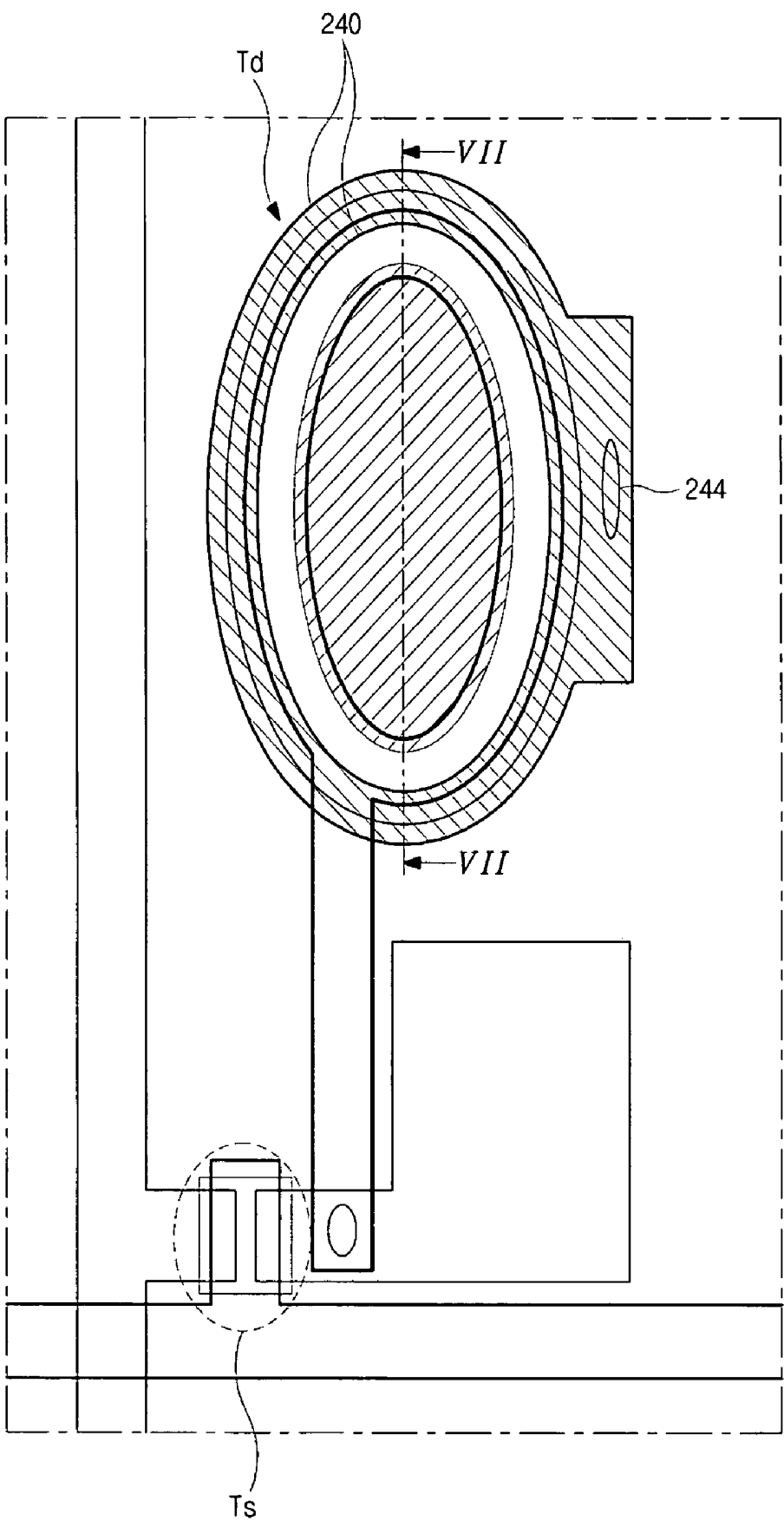


FIG. 6F

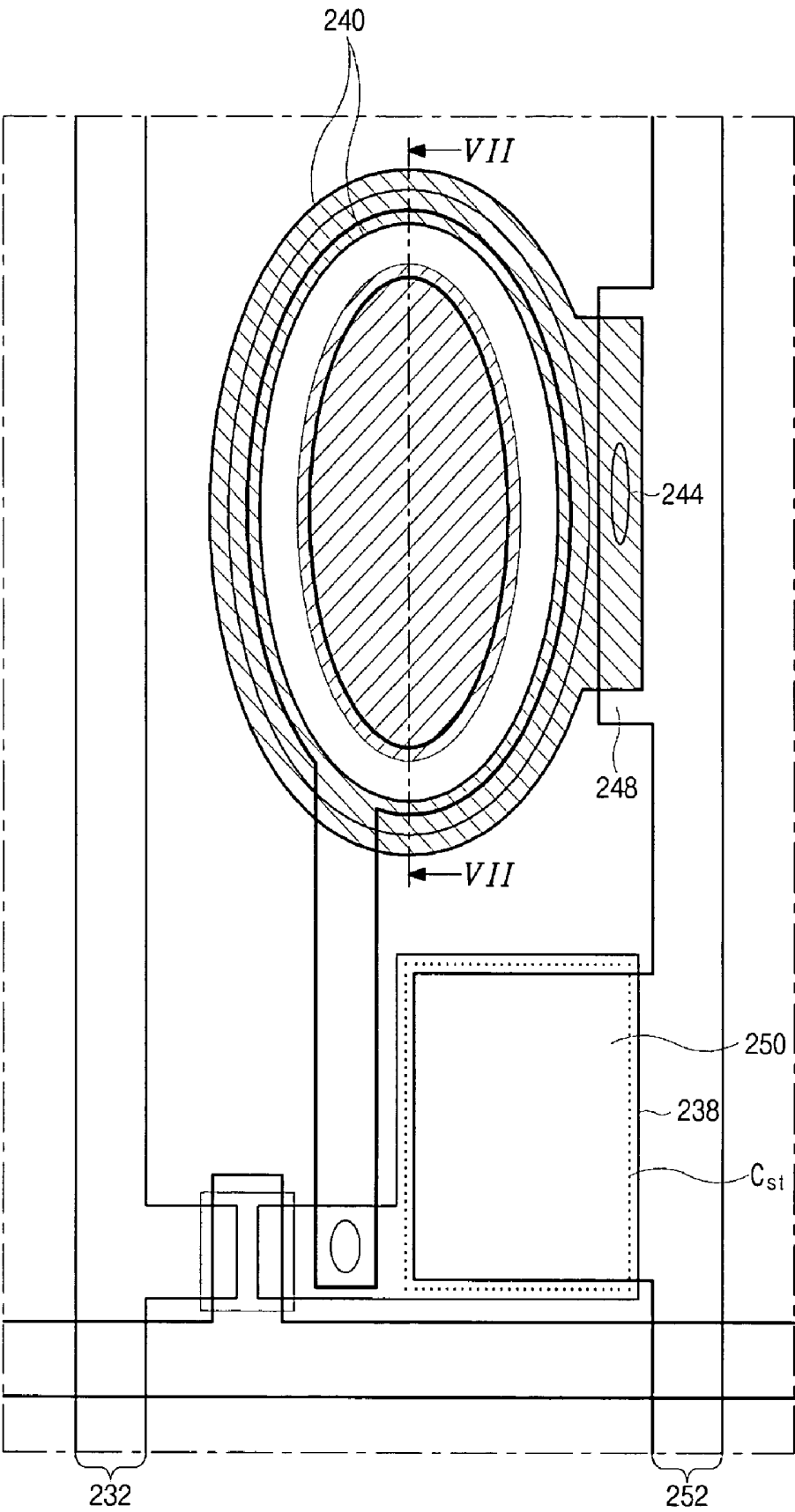


FIG. 6G

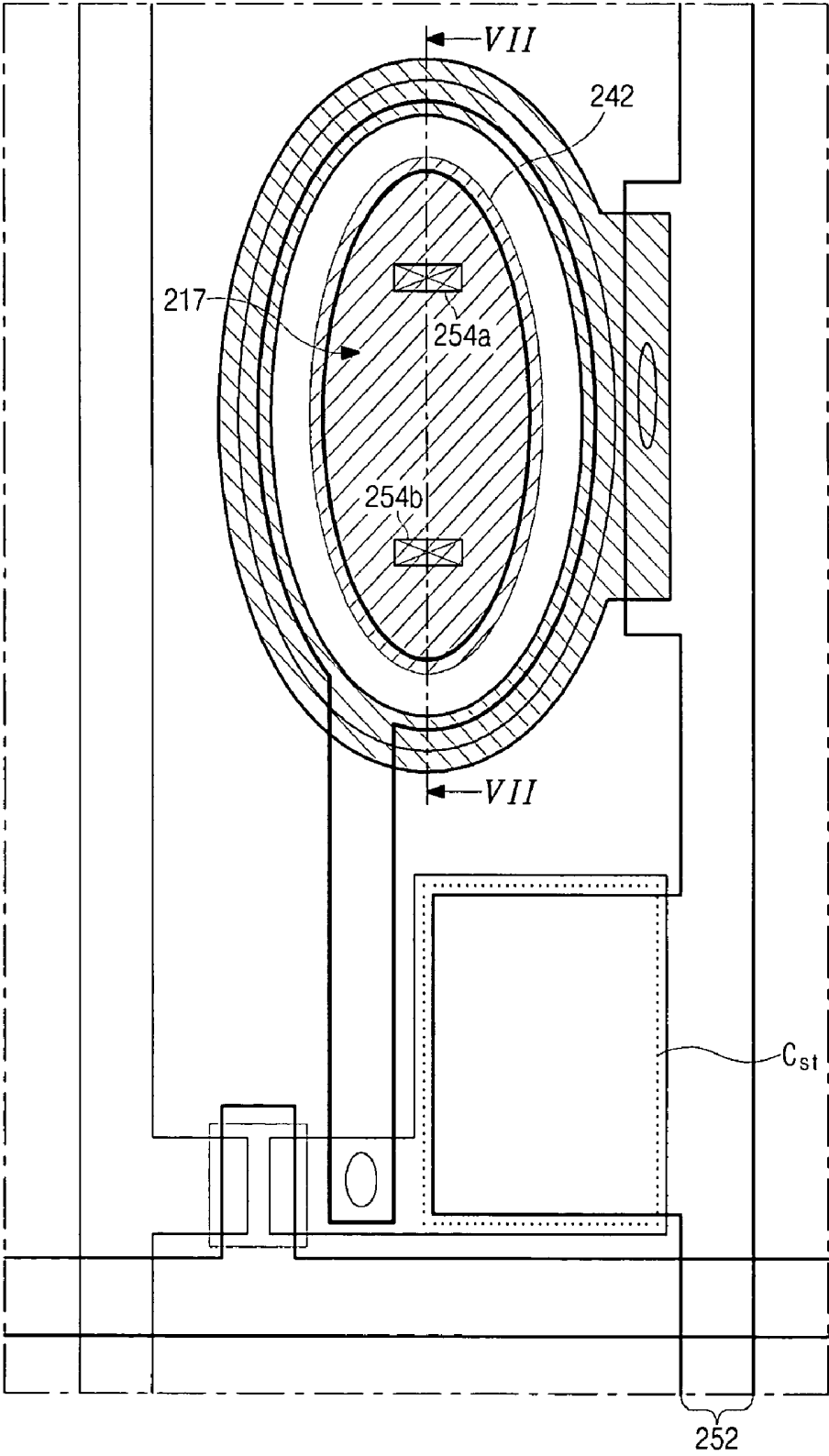


FIG. 6H

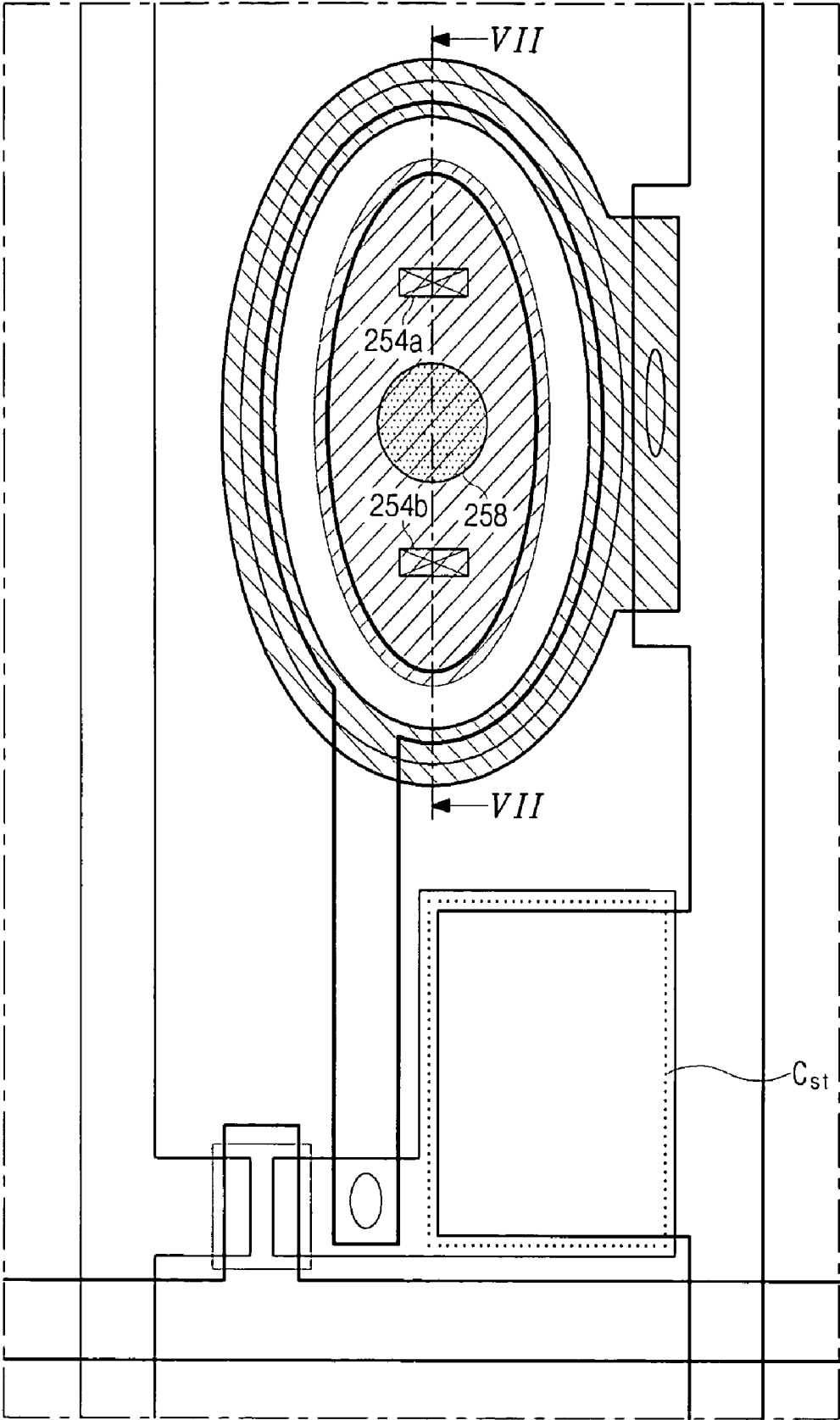


FIG. 6I

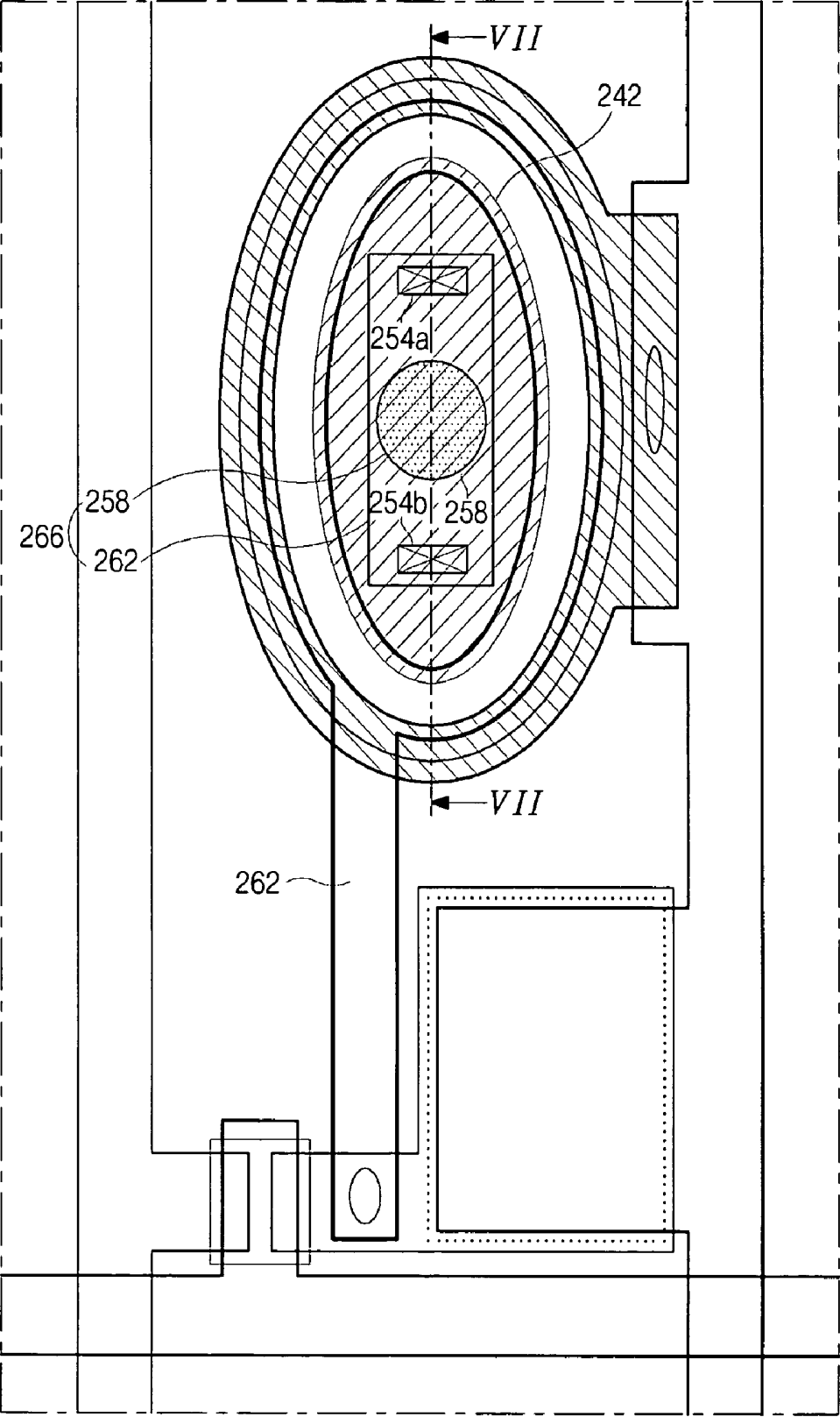


FIG. 7A

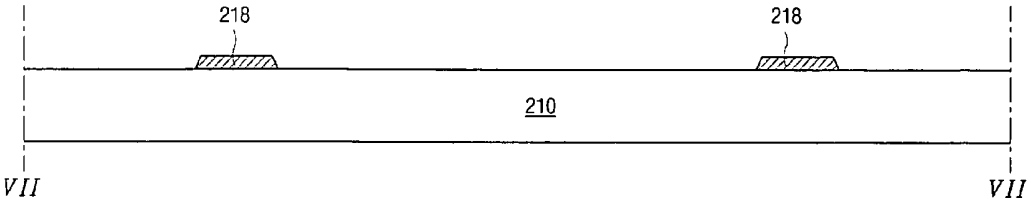


FIG. 7B

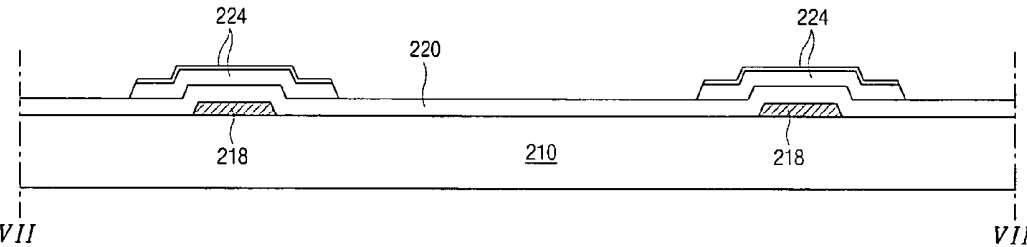


FIG. 7C

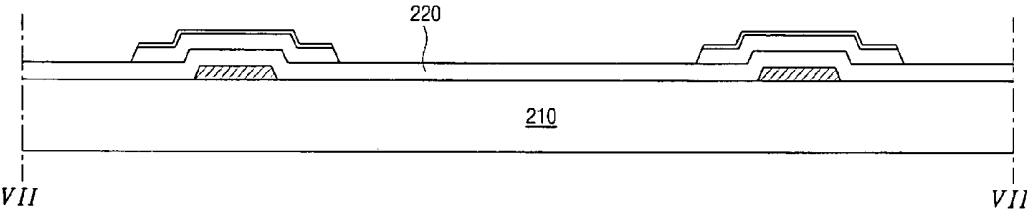


FIG. 7D

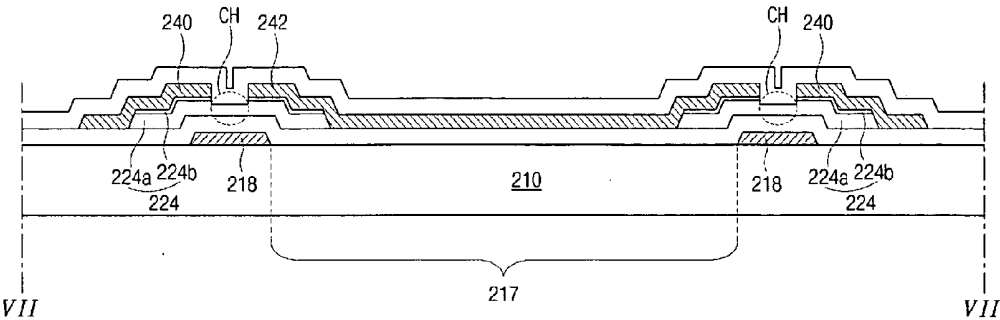


FIG. 7E

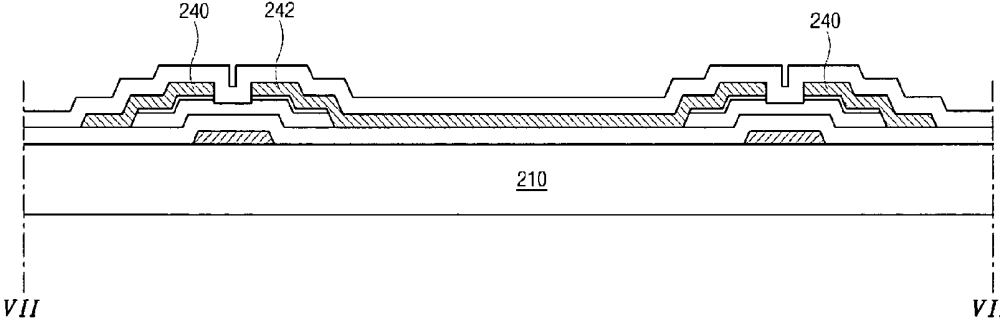


FIG. 7F

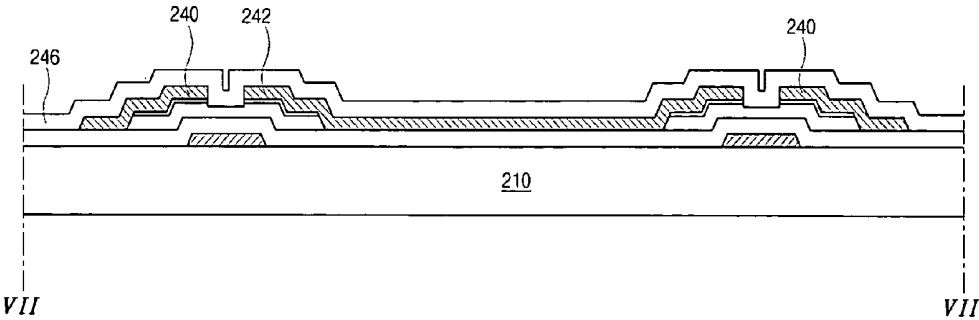


FIG. 7G

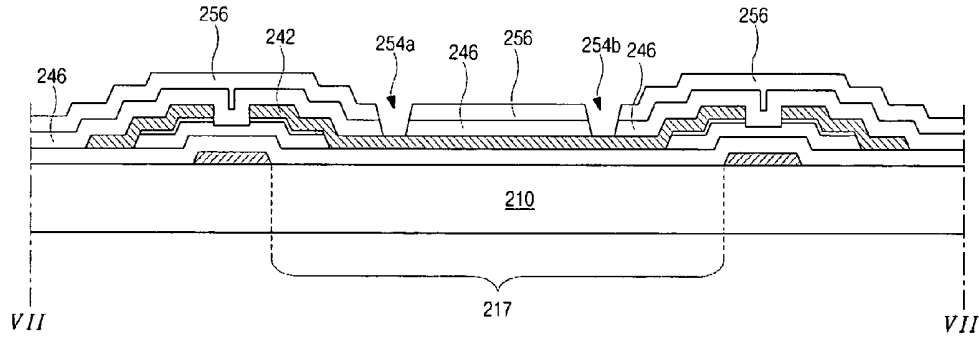


FIG. 7H

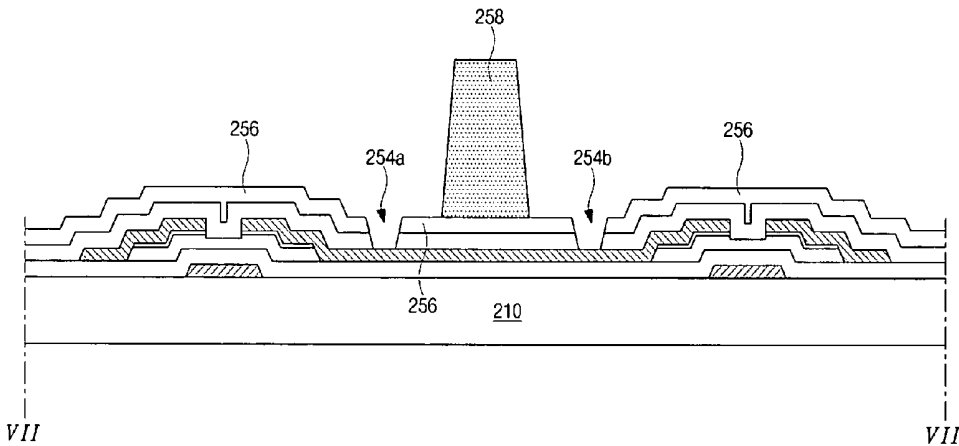


FIG. 7I

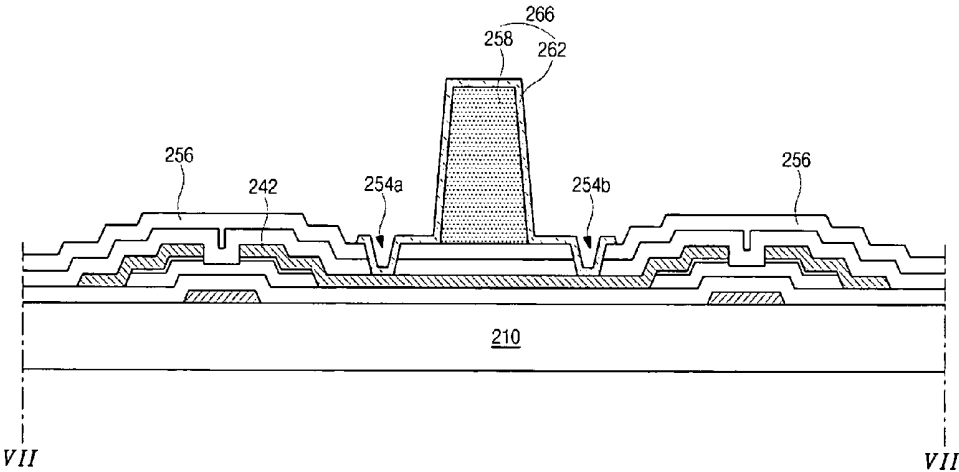
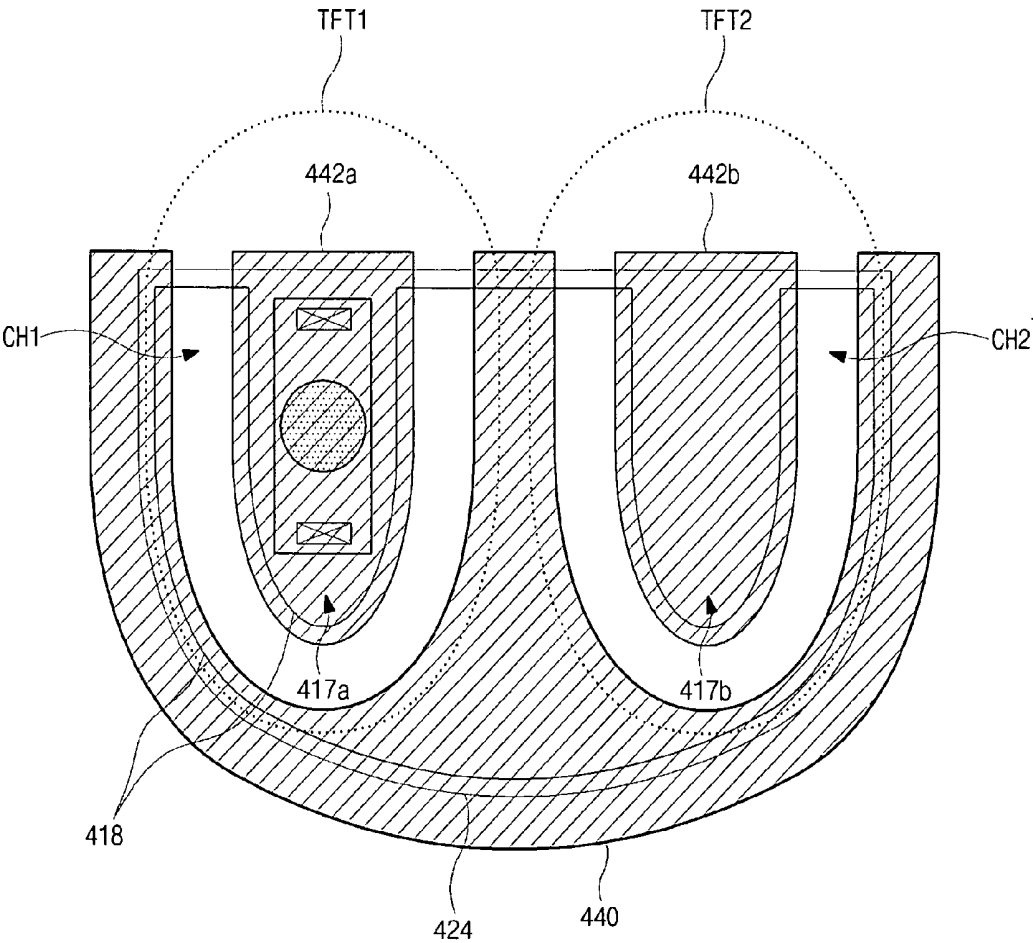


FIG. 9



DUAL PANEL TYPE ORGANIC ELECTROLUMINESCENT DEVICE AND METHOD OF FABRICATING THE SAME

[0001] The present invention claims the benefit of Korean Patent Application No. 2003-0097983 filed in Korea on Dec. 26, 2003, which is hereby incorporated by reference.

BACKGROUND OF THE INVENTION

[0002] 1. Field of the Invention

[0003] The present invention relates to an organic electroluminescent device, and more particularly, to a dual panel type organic electroluminescent device and a method of fabricating the same.

[0004] 2. Discussion of the Related Art

[0005] Among flat panel displays (FPDs), organic electroluminescent (EL) devices have been of particular interest in research and development because they are light-emitting type displays having a wide viewing angle as well as a high contrast ratio in comparison to liquid crystal display (LCD) devices. Organic EL devices are lightweight and small, as compared to other types of display devices, because they do not need a backlight. Organic EL devices have other desirable characteristics, such as low power consumption, superior brightness and fast response time. When driving the organic EL devices, only a low direct current (DC) voltage is required. Moreover, a fast response time can be obtained. Unlike LCD devices, organic EL devices are entirely formed in a solid phase arrangement. Thus, organic EL devices are sufficiently strong to withstand external impacts and also have a greater operational temperature range. Moreover, organic EL devices are fabricated in a relatively simple process involving few processing steps. Thus, it is much cheaper to produce an organic EL device in comparison to an LCD device or a plasma display panel (PDP). In particular, only deposition and encapsulation processes are necessary for manufacturing organic EL devices.

[0006] FIG. 1 is a cross-sectional view of a related art organic electroluminescent device. Referring to FIG. 1, first and second substrates 10 and 60, which have inner surfaces facing each other and are spaced apart from each other, have a plurality of pixel regions "P." An array layer "AL" is formed on an inner surface of the first substrate 10. The array layer "AL" includes a driving thin film transistor (TFT) "Td" in each pixel region "P." A first electrode 48 connected to the driving TFT "Td" is formed on the array layer "AL" in each pixel region "P." Red, green and blue organic electroluminescent (EL) layers 54 are alternately formed on the first electrode 48. A second electrode 56 is formed on the organic EL layer 54. The first and second electrodes 48 and 56, and the organic EL layer 54 interposed therebetween constitute an organic EL diode "D_{EL}." The organic EL device is a bottom type device where light is emitted from the organic EL layer 54 through the first electrode 48 and out of the first substrate 10.

[0007] The second substrate 60 is used as an encapsulation substrate. The second substrate 60 has a concave portion 62 at its inner center. The concave portion 62 is filled with a moisture absorbent desiccant 64 that removes moisture and oxygen to protect the organic EL diode "D_{EL}." The inner surface of the second substrate 60 is spaced apart from the second electrode 56. The first and second substrates 10 and

60 are attached with a sealant 70 at a peripheral portion of the first and second substrates 10 and 60.

[0008] FIG. 2A is a plan view of an organic electroluminescent device according to the related art. Referring to FIG. 2A, a gate line 22 crosses a data line 42 and a power line 28. The data line 42 and the power line 28 are spaced apart from each other. A pixel region "P" is defined by the gate line 22, the data line 42 and the power line 28. A switching thin film transistor (TFT) "Ts" is disposed adjacent to the crossing of the gate line 22 and the data line 42. A driving TFT "Td" is connected to the switching TFT "Ts" and the power line 28. A storage capacitor "Cst" uses a power electrode 26 extending from the power line 28 as a first capacitor electrode and an active pattern 16 extending from a switching semiconductor layer 31 of the switching TFT "Ts" as a second capacitor electrode.

[0009] FIG. 2B is a cross-sectional view taken along line "Ib-Ib" of FIG. 2A. In FIG. 2B, a buffer layer 12 is formed on a first substrate 10. A driving semiconductor layer 14 and an active pattern 16 separated from each other are formed on the buffer layer 12. A gate insulating layer 18 and a gate electrode 20 are sequentially formed on the driving semiconductor layer 14. The driving semiconductor layer 14 includes an active region "Iic" corresponding to the gate electrode 20, and drain and source regions "Iid" and "Iie" at both sides of the active region "Iic."

[0010] A first passivation layer 24 is formed on the gate electrode 20 and the active pattern 16. A power electrode 26 corresponding to the active pattern 16 is formed on the first passivation layer 24.

[0011] A second passivation layer 30 is formed on the power electrode 26. The first and second passivation layers 24 and 30 have first and second contact holes exposing portions of the drain and source regions "Iid" and "Iie," respectively. Moreover, the second passivation layer 30 has a third contact hole 36 exposing a portion of the power electrode 26.

[0012] Drain and source electrodes 40 and 38 are formed on the second passivation layer 30. The drain electrode 40 is connected to the drain region "Iid" of the driving semiconductor layer 14 through the first contact hole 32. The source electrode 38 is connected to the source region "Iie" of the driving semiconductor layer 14 through the second contact hole 34 and connected to the power electrode 26 through the third contact hole 36.

[0013] A third passivation layer 44 is formed on the drain and source electrodes 40 and 38. The third passivation layer 44 has a drain contact hole 46 exposing a portion of the drain electrode 40. The driving semiconductor layer 14, the gate electrode 20, the drain electrode 40 and the source electrode 38 constitute the driving thin film transistor (TFT) "Td."

[0014] A first electrode 48 connected to the drain electrode 40 through the drain contact hole 46 is formed on the third passivation layer 44. An insulating interlayer 50 having an open portion exposing the first electrode 48 is formed on the first electrode 48. An organic electroluminescent (EL) layer 54 is formed on the insulating interlayer 50. A second electrode 56 is formed on the organic EL layer 54. The organic EL layer 54 contacts the first electrode 48 through the open portion of the insulating interlayer 50. The first and

second electrodes **48** and **56** and the organic EL layer **54** interposed therebetween constitute an organic EL diode "D_{EL}."

[0015] In an organic EL device according to the related art, an array layer and an organic EL diode are formed on a first substrate, and an additional second substrate is attached with the first substrate for encapsulation. However, when the array layer and the organic EL diode are formed on one substrate in such a manner, production yield of the organic EL device is determined by multiplying the TFT's yield with the organic EL diode's yield. Since the organic EL diode's yield is relatively low, the production yield of the overall EL device is limited by the organic EL diode's yield. For example, even when a TFT is well fabricated, an organic EL device using a thin film of about 1000 Å thickness can be judged as bad due to defects in an organic EL layer. This results in loss of material and increased production cost.

[0016] In general, organic EL devices are classified into bottom emission types and top emission types according to an emission direction of light used for displaying images through the organic EL devices. Bottom emission type organic EL devices have the advantages of high encapsulation stability and high process flexibility. However, the bottom emission type organic EL devices are ineffective for high resolution devices because they have poor aperture ratios. In contrast, top emission type organic EL devices have a higher expected life span because they are more easily designed and they have a high aperture ratio. However, in top emission type organic EL devices, the cathode is generally formed on an organic EL layer. As a result, transmittance and optical efficiency of top emission type organic EL devices are reduced because a limited number of materials may be selected. If a thin film-type passivation layer is formed to prevent a reduction of the light transmittance, the thin film-type passivation layer may fail to prevent infiltration of exterior air into the device.

SUMMARY OF THE INVENTION

[0017] Accordingly, the present invention is directed to an organic electroluminescent device and a method of fabricating the same that substantially obviate one or more of the problems due to limitations and disadvantages of the related art.

[0018] An object of the present invention is to provide an organic electroluminescent device having an improved production yield.

[0019] Another object of the present invention is to provide an organic electroluminescent device having a high resolution.

[0020] Another object of the present invention is to provide an organic electroluminescent device having a high aperture ratio.

[0021] Another object of the present invention is to provide a method of fabricating an organic electroluminescent device having an improved production yield.

[0022] Another object of the present invention is to provide a method of fabricating an organic electroluminescent device having a high resolution.

[0023] Another object of the present invention is to provide a method of fabricating an organic electroluminescent device having a high aperture ratio.

[0024] Additional features and advantages of the invention will be set forth in the description which follows, and in part will be apparent from the description, or may be learned by practice of the invention. The objectives and other advantages of the invention will be realized and attained by the structure particularly pointed out in the written description and claims hereof as well as the appended drawings.

[0025] To achieve these and other advantages and in accordance with the purpose of the present invention, as embodied and broadly described, an organic electroluminescent device includes first and second substrates facing each other and spaced apart from each other; a gate line on an inner surface of the first substrate; a data line and a power line crossing the gate line and spaced apart from each other; a switching thin film transistor connected to the gate line and the data line; a driving thin film transistor connected to the switching thin film transistor and the power line, the driving thin film transistor including a channel region having a ring shape; an electric connection pattern connected to the driving thin film transistor, the connection pattern being disposed over the driving thin film transistor; and an organic electroluminescent diode on an inner surface of the second substrate, the organic electroluminescent diode being connected to the electric connection pattern.

[0026] In another aspect, an organic electroluminescent device includes first and second substrates facing each other and spaced apart from each other; a gate line on an inner surface of the first substrate; a data line and a power line crossing the gate line and spaced apart from each other; a switching thin film transistor connected to the gate line and the data line; a driving thin film transistor connected to the switching thin film transistor and the power line, the driving thin film transistor having a channel region including at least two-half ring shapes; an electric connection pattern connected to the driving thin film transistor, the connection pattern being disposed over the driving thin film transistor; and an organic electroluminescent diode on an inner surface of the second substrate, the organic electroluminescent diode being connected to the electric connection pattern.

[0027] In another aspect, a method of fabricating an organic electroluminescent device includes forming a gate line on a first substrate; forming a data line crossing the gate line; forming a power line spaced apart from the data line; forming a switching thin film transistor connected to the gate line and the data line; forming a driving thin film transistor connected to the switching thin film transistor and the power line, the driving thin film transistor having a channel region having a ring shape; forming an organic electroluminescent diode on a second substrate; forming an electric connection pattern over one of the driving thin film transistor and the organic electroluminescent diode; and attaching the first and second substrates such that the electric connection pattern electrically connects the driving thin film transistor and the organic electroluminescent diode.

[0028] In another aspect, a method of fabricating an organic electroluminescent device includes forming a gate line on a first substrate; forming a data line crossing the gate line; forming a power line spaced apart from the data line; forming a switching thin film transistor connected to the gate line and the data line; forming a driving thin film transistor connected to the switching thin film transistor and the power

line, the driving thin film transistor having a channel region including at least two-half ring shapes; forming an organic electroluminescent diode on a second substrate; forming an electric connection pattern over one of the driving thin film transistor and the organic electroluminescent diode; and attaching the first and second substrates such that the electric connection pattern electrically connects the driving thin film transistor and the organic electroluminescent diode.

[0029] It is to be understood that both the foregoing general description and the following detailed description are exemplary and explanatory and are intended to provide further explanation of the invention as claimed.

BRIEF DESCRIPTION OF THE DRAWINGS

[0030] The accompanying drawings, which are included to provide a further understanding of the invention and are incorporated in and constitute a part of this specification, illustrate embodiments of the invention and together with the description serve to explain the principles of the invention. In the drawings:

[0031] FIG. 1 is a cross-sectional view of a related art organic electroluminescent device.

[0032] FIG. 2A is a plan view of an organic electroluminescent device according to the related art.

[0033] FIG. 2B is a cross-sectional view taken along line "IIb-IIb" of FIG. 2A.

[0034] FIG. 3 is a cross-sectional view of an exemplary dual panel type organic electroluminescent device according to an embodiment of the present invention.

[0035] FIG. 4A is a plan view of a single pixel region of a substrate for an exemplary dual panel type organic electroluminescent device according to an embodiment of the present invention.

[0036] FIG. 4B is a cross-sectional view taken along line "IVb-IVb" of FIG. 4A.

[0037] FIG. 5A is a plan view showing a pixel region of a substrate for an exemplary dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0038] FIG. 5B is a cross-sectional view taken along line "Vb-Vb" of FIG. 5A.

[0039] FIG. 6A is a plan view of the formation of a connection line and a gate electrode in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0040] FIG. 6B is a plan view of the formation of a switching semiconductor layer and a driving semiconductor layer in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0041] FIG. 6C is a plan view of the formation of a contact hole in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0042] FIG. 6D is a plan view of the formation of switching and driving electrodes in a process of fabricating a

substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0043] FIG. 6E is a plan view of the formation of a first passivation layer in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0044] FIG. 6F is a plan view of the formation of a power electrode and a capacitor electrode in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0045] FIG. 6G is a plan view of the formation of a second passivation layer in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0046] FIG. 6H is a plan view of the formation of a protrusion pattern in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0047] FIG. 6I is a plan view of the formation of an electric connection pattern in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0048] FIG. 7A is a cross-sectional view taken along line "VII-VII" of FIG. 6A.

[0049] FIG. 7B is a cross-sectional view taken along line "VII-VII" of FIG. 6B.

[0050] FIG. 7C is a cross-sectional view taken along line "VII-VII" of FIG. 6C.

[0051] FIG. 7D is a cross-sectional view taken along line "VII-VII" of FIG. 6D.

[0052] FIG. 7E is a cross-sectional view taken along line "VII-VII" of FIG. 6E.

[0053] FIG. 7F is a cross-sectional view taken along line "VII-VII" of FIG. 6F.

[0054] FIG. 7G is a cross-sectional view taken along line "VII-VII" of FIG. 6G.

[0055] FIG. 7H is a cross-sectional view taken along line "VII-VII" of FIG. 6H.

[0056] FIG. 7I is a cross-sectional view taken along line "VII-VII" of FIG. 6I.

[0057] FIG. 8 is a plan view of an exemplary driving thin film transistor for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

[0058] FIG. 9 is a plan view of an exemplary driving thin film transistor for a dual panel type organic electroluminescent device according to another embodiment of the present invention.

DETAILED DESCRIPTION OF THE EMBODIMENTS

[0059] Reference will now be made in detail to the preferred embodiments of the present invention, examples of which are illustrated in the accompanying drawings.

[0060] FIG. 3 is a cross-sectional view of an exemplary dual panel type organic electroluminescent device according to an embodiment of the present invention. Referring to FIG. 3, a first substrate 110 and a second substrate 170, which have inner surfaces facing each other and are spaced apart from each other, include a plurality of pixel regions "P." An array layer "A" including a thin film transistor (TFT) "T" is formed on an inner surface of the first substrate 110. A connection pattern 166 connected to the TFT "T" is formed on the array layer "A." The connection pattern 166 has a thickness such that the array layer "A" on the first substrate 110 is connected to an organic electroluminescent (EL) diode "E" on the second substrate 170 through the connection pattern 166. For example, the connection pattern 166 may have a thickness corresponding to a distance, which is a cell gap between the first and second substrates 110 and 170. Moreover, the TFT "T" may be a driving TFT, which applies a current to the organic EL diode. The TFT "T" may further have an inverted staggered structure using amorphous silicon.

[0061] A first electrode 182 is formed on an entire inner surface of the second substrate 170. An interlayer insulating layer 184 and a plurality of separators 186 are sequentially formed on the first electrode 182 in a non-pixel region "NP" between the adjacent pixel regions "P." The separators 186 may each have a tapered shape. An organic luminescent layer 188 and a second electrode 190 are sequentially formed on the first electrode 182 between adjacent separators 186. Each of the separators 186 may have a thickness and a shape such that the organic luminescent layer 188 and the second electrode 190 are automatically separated in each pixel region "P" by the separators 186. The organic luminescent layer 188 may include red, green and blue luminescent layers 188a, 188b and 188c alternately disposed in each pixel region "P."

[0062] The first electrode 182, the second electrode 190 and the organic luminescent layer 188 between the first electrode 182 and the second electrode 190 form an organic electroluminescent (EL) diode "E." The first electrode 182 may include a transparent material such that light from the organic luminescent layer 188 is emitted through the first electrode 182, i.e., a top emission type. In one embodiment of the present invention, the first electrode 182 is an anode and the second electrode 190 is a cathode. In this case, the first electrode 182 may include a transparent conductive material such as indium-tin-oxide (ITO) and indium-zinc-oxide (IZO). In addition, the first substrate 110 and the second substrate 170 may be attached by a seal pattern 192 in a boundary portion of the first substrate 110 and the second substrate 170.

[0063] The exemplary dual panel type organic EL device depicted in FIG. 3 has an improved production yield and longer lifetime because the array layer "A" including the TFT "T" and the organic EL diode "E" are formed on their own respective substrates. In addition, TFT design is easier because the dual panel type organic EL diode is a top emission type. Moreover, the exemplary dual panel type organic EL device depicted in FIG. 3 provides high resolution and high aperture ratio. Moreover, the fabrication process is simplified because the organic luminescent layer 188 and the second electrode 190 are automatically patterned by the plurality of separators 186 without using an additional shadow mask.

[0064] Although not shown in FIG. 3, the dual panel type organic EL device may further include a full-color displaying element, such as a single layer of color filter and a double layer of color filter and color-changing medium for displaying full-color. When the full-color displaying element is formed in the dual panel type organic EL device, the organic luminescent layer 188 may include a luminescent material emitting a single color.

[0065] FIG. 4A is a plan view of a single pixel region of a substrate for an exemplary dual panel type organic electroluminescent device according to an embodiment of the present invention. FIG. 4B is a cross-sectional view taken along line "IVb-IVb" of FIG. 4A. Referring to FIGS. 4A and 4B, a gate line 114 (shown in FIG. 4A) having a switching gate electrode 112 is formed on a first substrate 110 along a first direction. A driving gate electrode 118 having an island shape is formed on the first substrate 110 along a second direction perpendicular to the first direction. A connection line 116 (shown in FIG. 4A) extends from the driving gate electrode 118 to an adjacent portion of the switching gate electrode 112. A gate insulating layer 120 is formed on the switching gate electrode 112, the gate line 114, the connection line 116 and the driving gate electrode 118. A first contact hole 130 is provided through the gate insulating layer 120. The first contact hole exposes a portion of the connection line 116.

[0066] A switching semiconductor layer 122 and a driving semiconductor layer 124 are formed on the gate insulating layer 120 to correspond to the switching gate electrode 112 and the driving gate electrode 118, respectively. The driving semiconductor layer 124 has an island shape. The driving semiconductor layer 124 also includes an active layer 124a and an ohmic contact layer 124b. The active layer 124a may include an intrinsic amorphous silicon. The ohmic contact layer 124b may include an impurity-doped amorphous silicon. Although not shown in FIG. 4B, the switching semiconductor layer 122 may have the same cross-sectional structure as the driving semiconductor layer 124. The switching semiconductor layer 122 and the driving semiconductor layer 124 may each include one of an amorphous silicon and a microcrystalline silicon.

[0067] A switching source electrode 134 and a switching drain electrode 136 spaced apart from each other are formed on the switching semiconductor layer 122. In addition, a driving source electrode 140 and a driving drain electrode 142 having an island shape and spaced apart from each other are formed on the driving semiconductor layer 124. A data line 132 is connected to the switching source electrode 134. The data line 132 is disposed along the second direction. The switching drain electrode 136 is connected to the connection line 116 through the first contact hole 130. A first capacitor electrode 138 extends from the switching drain electrode 136.

[0068] The switching gate electrode 112, the switching semiconductor layer 122, the switching source electrode 134 and the switching drain electrode 136 form a switching thin film transistor (TFT) "Ts." The driving gate electrode 118, the driving semiconductor layer 124, the driving source electrode 140 and the driving drain electrode 142 form a driving thin film transistor (TFT) "Td." The switching semiconductor layer 122 between the switching source electrode 134 and the switching drain electrode 136 forms a

channel region for carrier transmissions. Similarly, the driving semiconductor layer **124** between the driving source electrode **140** and the driving drain electrode **142** is also a channel region.

[0069] A first passivation layer **146** is formed on the switching TFT “Ts” and the driving TFT “Td.” A second contact hole **144** is provided through the first passivation layer **146**. The second contact hole **144** exposes a portion of the driving source electrode **140**.

[0070] A power electrode **148**, a second capacitor electrode **150** and a power line **152** are formed on the first passivation layer **146**. The power electrode **148** and the second capacitor electrode **150** extend from the power line **152**, which is spaced apart and parallel to the data line **132**. In addition, the power electrode **148** is connected to the driving source electrode **140** through the second contact hole **144**, and the second capacitor electrode **150** corresponds to the first capacitor electrode **138** to constitute a storage capacitor “Cst” with the first passivation layer **146** interposed therebetween. The gate line **114**, the data line **132** and the power line **152** define a pixel region “P.”

[0071] A second passivation layer **156** having a third contact hole **154** through the first passivation layer **146** is formed on the power electrode **148**, the second capacitor electrode **150** and the power line **152**. The third contact hole **154** exposes a portion of the driving drain electrode **142**. A protrusive pattern **158** is formed on the second passivation layer **156** in the pixel region “P” adjacent to the third contact hole **154**. A connection electrode **162** connected to the driving drain electrode **142** through the third contact hole **154** is formed on the protrusive pattern **158**. The protrusive pattern **158** and the connection electrode **162** thereon form an electric connection pattern **166**.

[0072] In the dual panel type organic EL device according to an embodiment of the present invention, the TFT may have a bottom gate structure based on production cost and efficiency. Accordingly, amorphous silicon or microcrystalline silicon may be used for the active layer. The microcrystalline silicon includes fine grains generated by injecting a high quantity of hydrogen. Since a TFT using amorphous silicon has a mobility of less than about $1 \text{ cm}^2/\text{V}\cdot\text{sec}$, the TFT is required to have a high width-to-length (W/L) ratio to generate a sufficient driving current for an organic EL device.

[0073] In a dual panel type organic EL device, the area for the electric connection pattern **166** contacting the first and second substrates decreases in accordance with an increase in the W/L ratio of the driving TFT Td. Moreover, when the connection electrode **162** does not completely wrap the protrusive pattern **158** and a periphery thereof, the connection electrode **162** may be torn or lifted from the protrusive pattern **158**. Accordingly, a sufficient area is required for completely wrapping the protrusive pattern.

[0074] FIG. 5A is a plan view showing a pixel region of a substrate for an exemplary dual panel type organic electroluminescent device according to another embodiment of the present invention. FIG. 5B is a cross-sectional view taken along line “Vb-Vb” of FIG. 5A. Referring to FIGS. 5A and 5B, a driving gate electrode **218** having a ring shape extends from a connection line **216** connected to a switching drain electrode **236** of a switching thin film transistor (TFT)

“Ts.” The driving gate electrode **218** includes an open portion **217**. In an embodiment of the present invention, the open portion **217** has a circular shape. In other embodiments of the present invention, the open portion **217** may have an elliptical shape.

[0075] A gate insulating layer **220** is formed on the driving gate electrode **218** and the connection line **216**. A driving semiconductor layer **224** is formed on the gate insulating layer **220** corresponding to the driving gate electrode **218**. A first contact hole **230** is provided through the gate insulating layer **220**. The first contact hole **230** exposes a portion of the connection line **216**. The driving semiconductor layer **224** includes one of an amorphous silicon and a microcrystalline silicon. In addition, the driving semiconductor layer **224** may include a driving active layer **224a** and a driving ohmic contact layer **224b**. The driving active layer **224a** may include an intrinsic semiconductor material and the driving ohmic contact layer **224b** may include an impurity-doped semiconductor material.

[0076] A driving source electrode **240** and a driving drain electrode **242** are spaced apart from each other and are formed on the driving semiconductor layer **224**. The driving source electrode **240** and the driving drain electrode **242** overlap an outer edge portion of the driving gate electrode **218** and an inner edge portion of the driving gate electrode **218**, respectively. Accordingly, the driving source electrode **240** is disposed to surround the driving gate electrode **218**, and the driving drain electrode **242** is disposed in the open portion **217** of the driving gate electrode **218**. A portion of the driving active layer **224a** is exposed through a space between the driving source electrode **240** and the driving drain electrode **242** to form a driving channel region “CH.” In addition, the driving gate electrode **218**, the driving semiconductor layer **224**, the driving source electrode **240** and the driving drain electrode **242** form a driving thin film transistor (TFT) “Td.”

[0077] A first passivation layer **246** is formed on the driving TFT “Td.” A power electrode **248** is formed on the first passivation layer **246**. A second contact hole **244** is provided through the first passivation layer **246**. The second contact hole **244** exposes a portion of the driving source electrode **240**. The power electrode **248** is connected to the driving source electrode **240** through the second contact hole **244**.

[0078] A second passivation layer **256** having third and fourth contact holes **254a** and **254b** through the first passivation layer **246** is formed on the power electrode **248**. The third and fourth contact holes expose portions of the driving drain electrode **242**. A protrusive pattern **258** is formed on the second passivation layer **256** over the driving drain electrode **242**. A connection electrode **262** is formed on the protrusive pattern **258**. The connection electrode **262** is connected to the driving drain electrode **242** through the third and fourth contact holes **254a** and **254b**. The protrusive pattern **258** and the connection electrode **262** thereon form an electric connection pattern **266**. Furthermore, the connection electrode **262** may completely wrap the protrusive pattern **258**.

[0079] In an embodiment of the present invention, a width “W” of the driving channel region “CH” having a ring shape corresponds to a circumference of a central circle of the driving channel region “CH.” Accordingly, a current may

flow along a radial direction of the ring shape between the driving source electrode 240 and the driving drain electrode 242. As a result, the width "W" and a W/L ratio of the driving channel region "CH" are sufficiently high in values for carrying a high driving current. Moreover, since the electric connection pattern 266 is formed over the driving drain electrode 242, a sufficient area is obtained for the electric connection pattern 266. Furthermore, a potential deterioration of the attachment due to a separator (not shown) is reduced because the connection pattern 266 is disposed in a central portion of the pixel region "P."

[0080] FIG. 6A is a plan view of the formation of a connection line and a gate electrode in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention. FIG. 7A is a cross-sectional view taken along line "VII-VII" of FIG. 6A. Referring to FIGS. 6A and 7A, a gate line 214 is formed on a first substrate 210 along a first direction. The gate line 214 includes a switching gate electrode 212. At the same time, a connection line 216 and a driving gate electrode 218 having a ring shape are formed on the first substrate 210. The connection line 216 is disposed along a second direction perpendicular to the first direction. The driving gate electrode 218 has an open portion 217 at a center portion thereof. In an embodiment of the present invention, the open portion 217 has a circular shape. In other embodiments of the present invention, the open portion 217 may have an elliptical shape.

[0081] FIG. 6B is a plan view of the formation of a switching semiconductor layer and a driving semiconductor layer in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention. FIG. 7B is a cross-sectional view taken along line "VII-VII" of FIG. 6B. Referring to FIGS. 6B and 7B, a gate insulating layer 220 is formed on the substrate 210 including the gate line 214. An intrinsic semiconductor material and an impurity-doped semiconductor material are sequentially deposited on the gate insulating layer 220. Then, a switching semiconductor layer 222 and a driving semiconductor layer 224 are formed on the gate insulating layer 220. The switching semiconductor layer 222 and the driving semiconductor layer 224 correspond to the switching gate electrode 212 and the driving gate electrode 218, respectively. For example, the switching semiconductor layer 222 and the driving semiconductor layer 224 may include one of an amorphous silicon and a microcrystalline silicon.

[0082] FIG. 6C is a plan view of the formation of a contact hole in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention. FIG. 7C is a cross-sectional view taken along line "VII-VII" of FIG. 6C. Referring to FIGS. 6C and 7C, a first contact hole 230 is formed in the gate insulating layer 220. The first contact hole 230 exposes a portion of the connection line 216 through the gate insulating layer 220. As shown in FIG. 6C, the first contact hole 230 may be positioned near a crossing of the switching gate electrode 212 and the gate line 214.

[0083] FIG. 6D is a plan view of the formation of switching and driving electrodes in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present

invention. FIG. 7D is a cross-sectional view taken along line "VII-VII" of FIG. 6D. Referring to FIGS. 6D and 7D, a data line 232 is formed along the second direction on the substrate 210 including the gate insulating layer 220. The data line 232 includes a switching source electrode 234. The switching source electrode 234 overlaps the switching gate electrode 212. In addition, a switching drain electrode 236, a first capacitor electrode 238, a driving source electrode 240 and a driving drain electrode 242 are simultaneously formed. The switching drain electrode 236 spaced apart from the switching source electrode 234 overlaps the switching gate electrode 212 and is connected to the connection line 216 through the first contact hole 230. The first capacitor electrode 238 extends from the switching drain electrode 236.

[0084] The driving source electrode 240 having a ring shape and the driving drain electrode 242 having a circular shape overlap an outer edge portion of the driving gate electrode 218 and an inner edge portion of the driving gate electrode 218, respectively. The driving drain electrode 242 is disposed in the open portion 217. Thus, the driving drain electrode 242 covers a portion of the gate insulation pattern in the open portion 217. Specifically, the driving source electrode 240 has an extended pattern "EP" for establishing an electrical contact with a power electrode in a subsequent process. Although the extended pattern "EP" is shown with a rectangular shape in FIG. 6D, the extended pattern "EP" can have other shapes in other embodiments of the present invention.

[0085] As shown in FIG. 7D, the driving semiconductor layer 224 includes a driving active layer 224a including an intrinsic semiconductor material, and a driving ohmic contact layer 224b including an impurity-doped semiconductor material. Although not shown in FIGS. 6D and 7D, the switching semiconductor layer 222 also includes a switching active layer including an intrinsic semiconductor material, and a switching ohmic contact layer including an impurity-doped semiconductor material. The intrinsic semiconductor material is exposed between the switching source electrode 212 and the switching drain electrode 236 by removing the impurity-doped semiconductor material, thereby constituting a switching channel region "ch." Similarly, the intrinsic semiconductor material is exposed between the driving source electrode 240 and the driving drain electrode 242 to constitute a driving channel region "CH."

[0086] The switching gate electrode 212, the switching semiconductor layer 222, the switching source electrode 234 and the switching drain electrode 236 form a switching thin film transistor (TFT) "Ts." The driving gate electrode 218, the driving semiconductor layer 224, the driving source electrode 240 and the driving drain electrode 242 form a driving thin film transistor (TFT) "Td." A width "W" of the driving channel region "CH" has a ring shape corresponding to a circumference of a central circle of the driving channel region "CH." A current may flow along a radial direction of the ring shape between the driving source electrode 240 and the driving drain electrode 242. Thus, the width "W" and a W/L ratio of the driving channel region "CH" are sufficiently high in values to carry a high driving current.

[0087] FIG. 6E is a plan view of the formation of a first passivation layer in a process of fabricating a substrate for a dual panel type organic electroluminescent device accord-

ing to another embodiment of the present invention. **FIG. 7E** is a cross-sectional view taken along line “VII-VII” of **FIG. 6E**. Referring to **FIGS. 6E and 7E**, a first passivation layer **246** is formed on the switching TFT “Ts” and the driving TFT “Td.” The first passivation layer also covers the driving drain electrode in the open portion **217**. A second contact hole **244** is provided through the first passivation layer **246**. The second contact hole **244** exposes a portion of the driving source electrode **240**.

[0088] **FIG. 6F** is a plan view of the formation of a power electrode and a capacitor electrode in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention. **FIG. 7F** is a cross-sectional view taken along line “VII-VII” of **FIG. 6F**. Referring to **FIGS. 6F and 7F**, a power line **252** having a power electrode **248** and a second capacitor electrode **250** is formed on the first passivation layer **246** along the second direction. The power electrode **248** is connected to the driving source electrode **240** through the second contact hole **244**. The second capacitor electrode **250** overlaps the first capacitor electrode **238**. The first and second capacitor electrodes **238** and **250** form a storage capacitor “Cst” with a portion of the first passivation layer **246** interposed therebetween.

[0089] **FIG. 6G** is a plan view of the formation of a second passivation layer in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention. **FIG. 7G** is a cross-sectional view taken along line “VII-VII” of **FIG. 6G**. Referring to **FIGS. 6G and 7G**, a second passivation layer **256** is formed on the substrate including the power line **252** and the first passivation layer **242**. A third contact hole **254a** and a fourth contact hole **254b** are provided through the second passivation layer **256**. The third contact hole **254a** and the fourth contact hole **254b** expose a portion of the driving drain electrode **242** through the first passivation layer **246**. The third and fourth contact holes **254a** and **254b** are disposed in the open portion **217**.

[0090] **FIG. 6H** is a plan view of the formation of a protrusive pattern in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention. **FIG. 7H** is a cross-sectional view taken along line “VII-VII” of **FIG. 6H**. Referring to **FIGS. 6H and 7H**, a protrusive pattern **258** is formed on the second passivation layer **256** between the third contact hole **254a** and the fourth contact hole **254b**.

[0091] **FIG. 6I** is a plan view of the formation of an electric connection pattern in a process of fabricating a substrate for a dual panel type organic electroluminescent device according to another embodiment of the present invention. **FIG. 7I** is a cross-sectional view taken along line “VII-VII” of **FIG. 6I**. Referring to **FIGS. 6I and 7I**, a connection electrode **262** is formed on the protrusive pattern **258**. The connection electrode **262** is connected to the driving drain electrode **242** through the third and fourth contact holes **254a** and **254b**. The connection electrode **262** may completely wrap the protrusive pattern **258** to constitute an electric connection pattern with the protrusive pattern **258**.

[0092] **FIG. 8** is a plan view of an exemplary driving thin film transistor for a dual panel type organic electrolumines-

cent device according to another embodiment of the present invention. Referring to **FIG. 8**, a ring-shaped gate electrode **318** is formed on a substrate. Accordingly, the gate electrode **318** has a circular open portion **317**. A semiconductor layer **324** is formed over the gate electrode **318**. In addition, a ring-shaped source electrode **340** and a circular-shaped drain electrode **342** are formed on the semiconductor layer **324**.

[0093] The source electrode **340** overlaps an outer edge of the gate electrode **318**. The drain electrode **342** disposed in the open portion **317** overlaps an inner edge of the gate electrode **318**. The semiconductor layer **324** exposed between the source and drain electrodes **340** and **342** forms a channel region “CH.” The source electrode **340** and the drain electrode **342** may have concave portions “CP” exposing end portions of the semiconductor layer **324**. In the concave portions “CP,” since the source and drain electrodes **340** and **342** do not overlap the semiconductor layer **324**, a channel for current path is not generated in the semiconductor layer **324**. Accordingly, the channel region “CH” may be divided into four sub-regions by the concave portions “CP.”

[0094] For example, the source electrode **340** and the drain electrode **342** may have four concave portions “CP.” A driving thin film transistor (TFT) may include first to fourth TFTs “TFT1” to “TFT4” connected to one another in parallel with respect to the gate electrode **318**. Since a sum of currents passing through the first to fourth TFTs “TFT1” to “TFT4” corresponds to a driving current for an organic electroluminescent diode (not shown), the driving current increases in comparison to the related art arrangement. In addition, since the first to fourth TFTs “TFT1” to “TFT4” are connected to one another in parallel with respect to the gate electrode **318**, a total electric stress is uniformly dissipated into the first to fourth TFTs “TFT1” to “TFT4” and a stability of the driving TFT is improved. Although the driving TFT is shown to include four TFTs in parallel, the number of TFTs included in the driving TFT may vary in other embodiments of the present invention.

[0095] **FIG. 9** is a plan view of an exemplary driving thin film transistor for a dual panel type organic electroluminescent device according to another embodiment of the present invention. Referring to **FIG. 9**, a gate electrode **418** having a curved “W” shape is formed on a substrate. The gate electrode **418** includes a first concave portion **417a** and a second concave portion **417b**. Each of the first concave portion **417a** and the second concave portion **417b** is shaped as a half circle. A semiconductor layer **424** is formed over the gate electrode **418**.

[0096] A source electrode **440** having a curved “W” shape and first and second drain electrodes **442a** and **442b** are formed on the semiconductor layer **424**. Each of the first and second drain electrodes **442a** and **442b** is shaped as a half circle. The first and second drain electrodes **442a** and **442b** overlap inner edge portions of the gate electrode **418** in the first and second concave portions **417a** and **417b**, respectively. The source electrode **440** overlaps an outer edge portion of the gate electrode **418** opposite to the inner edge portion. The semiconductor layer **424** exposed between the first drain electrode **442a** and the source electrode **440** constitutes a first channel region “CH1” having a “U” shape or a half ring shape. The semiconductor layer **424** exposed between the second drain electrode **442b** and the source

electrode **440** constitutes a second channel region "CH2" having a "U" shape or a half ring shape. Accordingly, the gate electrode **418**, the semiconductor layer **424**, the source electrode **440** and the first drain electrode **442a** form a first thin film transistor (TFT) "T1" including the first channel region "CH1." The gate electrode **418**, the semiconductor layer **424**, the source electrode **440** and the second drain electrode **442b** form a second thin film transistor (TFT) "T2" including the second channel region "CH2." As a result, a driving TFT "Td" for an organic electroluminescent diode (not shown) may include the first and second TFTs "T1" and "T2" connected to each other in parallel with respect to the gate electrode **418**.

[0097] A protrusive pattern **458** may be formed over the first drain electrode **442a** and a connection electrode **462** may be formed over the protrusive pattern **458**. The connection electrode **462** may completely wrap the protrusive pattern **458** and may be connected to the first drain electrode **442a** through first and second contact holes **454a** and **454b**. Accordingly, the protrusive pattern **458** and the connection electrode **462** form an electric connection pattern **466**. Although the electric connection pattern **466** is formed over the first drain electrode **442a** in FIG. 9, the electric connection pattern **466** may be disposed over the second drain electrode **442b** or may be disposed both over the first and second drain electrodes **442a** and **442b** in other embodiments of the present invention. In addition, the gate electrode may include more than two concave portions in other embodiments of the present invention.

[0098] Although not shown in FIG. 9, a width of the channel region of the driving TFT corresponds to a sum of circumferences of two central half circles between the source electrode **440** and the drain electrodes **442a** and **442b**. Also not shown, a length of the channel region of the driving TFT corresponds to a distance between the source electrode **440** and the drain electrodes **442a** and **442b**. Accordingly, a current may flow in a radial direction of the two central half circles between the source electrode **440** and the drain electrodes **442a** and **442b**. As a result, the width and a W/L ratio of the driving TFT have are sufficiently high in values for carrying a high driving current.

[0099] According to embodiments of the present invention, a dual panel type organic electroluminescent device has some advantages. First, since array patterns and an organic EL diode are formed on the respective substrate, production yield and production management efficiency are improved. The lifetime of an organic EL device is also lengthened. Second, since the ELD is a top emission type, a thin film transistor can be easily designed, and a high resolution and a high aperture ratio can be obtained regardless of lower array patterns. Third, since an electric connection pattern is formed in a thin film transistor region, deterioration of the electric connection pattern due to a separator is prevented and production yield is improved. In addition, the performance of the driving thin film transistor is improved because of the ring-shaped thin film transistor.

[0100] It will be apparent to those skilled in the art that various modifications and variations can be made in the organic electroluminescent device and fabricating method thereof of the present invention without departing from the spirit or scope of the invention. Thus, it is intended that the present invention cover the modifications and variations of

this invention provided they come within the scope of the appended claims and their equivalents.

What is claimed is:

1. An organic electroluminescent device, comprising:
 - first and second substrates facing each other and spaced apart from each other;
 - a gate line on an inner surface of the first substrate;
 - a data line and a power line crossing the gate line and spaced apart from each other;
 - a switching thin film transistor connected to the gate line and the data line;
 - a driving thin film transistor connected to the switching thin film transistor and the power line, the driving thin film transistor including a channel region having a ring shape;
 - an electric connection pattern connected to the driving thin film transistor, the connection pattern being disposed over the driving thin film transistor; and
 - an organic electroluminescent diode on an inner surface of the second substrate, the organic electroluminescent diode being connected to the electric connection pattern.
2. The organic electroluminescent device according to claim 1, wherein the channel region has a width corresponding to a circumference of a central circle of the ring shape and a length corresponding to a width of the ring shape.
3. The organic electroluminescent device according to claim 1, wherein a current flows along a radial direction of the ring shape in the channel region.
4. The organic electroluminescent device according to claim 1, wherein the driving thin film transistor comprises:
 - a driving gate electrode having a ring shape having an open portion at a central portion thereof;
 - a driving semiconductor layer over the driving gate electrode; and
 - a driving source electrode and a driving drain electrode on the driving semiconductor layer, the driving source electrode having a ring shape and overlapping an outer edge portion of the driving gate electrode, the driving drain electrode having a circular shape in the open portion and overlapping an inner edge portion of the driving gate electrode.
5. The organic electroluminescent device according to claim 4, wherein the driving source electrode includes at least one source concave portion and the driving drain electrode includes at least one drain concave portion, the at least one source concave portion and the at least one drain concave portion facing each other and exposing end portions of the driving gate electrode.
6. The organic electroluminescent device according to claim 1, wherein the switching thin film transistor includes a switching gate electrode, a switching semiconductor layer over the switching gate electrode, a switching source electrode on the switching semiconductor layer and a switching drain electrode on the switching semiconductor layer, and the driving thin film transistor includes a driving gate electrode, a driving semiconductor layer over the driving

gate electrode, a driving source electrode on the driving semiconductor layer and a driving drain electrode on the driving semiconductor layer.

7. The organic electroluminescent device according to claim 6, wherein the switching semiconductor layer and the driving semiconductor layer includes one of an amorphous silicon and a microcrystalline silicon.

8. The organic electroluminescent device according to claim 6, wherein the electric connection pattern contacts the driving drain electrode and the organic electroluminescent diode.

9. The organic electroluminescent device according to claim 1, wherein the electric connection pattern includes a protrusive pattern extending from the first substrate to the second substrate and a connection electrode wrapping the protrusive pattern.

10. The organic electroluminescent device according to claim 1, wherein the channel region has an elliptical ring shape.

11. The organic electroluminescent device according to claim 1, wherein the electric connection pattern is disposed over a central portion of the ring shape.

12. An organic electroluminescent device, comprising:

first and second substrates facing each other and spaced apart from each other;

a gate line on an inner surface of the first substrate;

a data line and a power line crossing the gate line and spaced apart from each other;

a switching thin film transistor connected to the gate line and the data line;

a driving thin film transistor connected to the switching thin film transistor and the power line, the driving thin film transistor having a channel region including at least two-half ring shapes;

an electric connection pattern connected to the driving thin film transistor, the connection pattern being disposed over the driving thin film transistor; and

an organic electroluminescent diode on an inner surface of the second substrate, the organic electroluminescent diode being connected to the electric connection pattern.

13. The organic electroluminescent device according to claim 12, wherein the channel region has a width corresponding to a sum of circumferences of central half circles of the at least two-half ring shapes and a length corresponding to a width of the at least two-half ring shapes.

14. The organic electroluminescent device according to claim 12, wherein a current flows along a radial direction of the at least two-half ring shapes in the channel region.

15. The organic electroluminescent device according to claim 12, wherein the driving thin film transistor comprises:

a driving gate electrode of at least two-half ring shapes having at least two concave portions;

a driving semiconductor layer over the driving gate electrode; and

a driving source electrode, at least two driving drain electrodes on the driving semiconductor layer, the driving source electrode having at least two-half ring shapes and overlapping an outer edge portion of the

driving gate electrode, each of the at least two driving drain electrodes having a half circular shape in the at least two concave portions and overlapping an inner edge portion of the driving gate electrode.

16. The organic electroluminescent device according to claim 12, wherein the switching thin film transistor includes a switching gate electrode, a switching semiconductor layer over the switching gate electrode, a switching source electrode on the switching semiconductor layer and a switching drain electrode on the switching semiconductor layer, and the driving thin film transistor includes a driving gate electrode, a driving semiconductor layer over the driving gate electrode, a driving source electrode on the driving semiconductor layer and a driving drain electrode on the driving semiconductor layer.

17. The organic electroluminescent device according to claim 16, wherein the switching semiconductor layer and the driving semiconductor layer includes one of an amorphous silicon and a microcrystalline silicon.

18. The organic electroluminescent device according to claim 16, wherein the electric connection pattern contacts the driving drain electrode and the organic electroluminescent diode.

19. The organic electroluminescent device according to claim 12, wherein the electric connection pattern includes a protrusive pattern extending from the first substrate to the second substrate and a connection electrode wrapping the protrusive pattern.

20. The organic electroluminescent device according to claim 12, wherein the channel region includes at least two-elliptical half ring shapes.

21. The organic electroluminescent device according to claim 12, wherein the electric connection pattern is disposed over one of the at least two central portions of the at least two-half ring shapes.

22. A method of fabricating an organic electroluminescent device, comprising:

forming a gate line on a first substrate;

forming a data line crossing the gate line;

forming a power line spaced apart from the data line;

forming a switching thin film transistor connected to the gate line and the data line;

forming a driving thin film transistor connected to the switching thin film transistor and the power line, the driving thin film transistor having a channel region having a ring shape;

forming an organic electroluminescent diode on a second substrate;

forming an electric connection pattern over one of the driving thin film transistor and the organic electroluminescent diode; and

attaching the first and second substrates such that the electric connection pattern electrically connects the driving thin film transistor and the organic electroluminescent diode.

23. The method according to claim 22, wherein forming the driving thin film transistor comprises:

forming a driving gate electrode having a ring shape on the first substrate, the driving gate electrode having an open portion at a central portion thereof;

forming a driving semiconductor layer over the driving gate electrode; and

forming a driving source electrode and a driving drain electrode on the driving semiconductor layer, the driving source electrode having a ring shape and overlapping an outer edge portion of the driving gate electrode, the driving drain electrode having a circular shape in the open portion and overlapping an inner edge portion of the driving gate electrode.

24. The method according to claim 23, wherein forming the electric connection pattern comprises:

forming a passivation layer covering the driving thin film transistor, the passivation layer having a drain contact hole exposing a portion of the driving drain electrode;

forming a protrusive pattern on the passivation layer over the driving drain electrode; and

forming a connection electrode wrapping the protrusive pattern and connected to the driving drain electrode through the drain contact hole.

25. The method according to claim 24, wherein the drain contact hole includes first and second contact holes at both sides of the protrusive pattern.

26. The method according to claim 23, wherein the driving source electrode includes at least one source concave portion and the driving drain electrode includes at least one drain concave portion, the at least one source concave portion and the at least one drain concave portion facing each other and exposing end portions of the driving gate electrode.

27. The method according to claim 22, wherein forming an organic electroluminescent diode comprises:

forming a first electrode on the second substrate;

forming a separator having a tapered shape on the first electrode; and

sequentially forming an organic luminescent layer and a second electrode on the first electrode.

28. A method of fabricating an organic electroluminescent device, comprising:

forming a gate line on a first substrate;

forming a data line crossing the gate line;

forming a power line spaced apart from the data line;

forming a switching thin film transistor connected to the gate line and the data line;

forming a driving thin film transistor connected to the switching thin film transistor and the power line, the driving thin film transistor having a channel region including at least two-half ring shapes;

forming an organic electroluminescent diode on a second substrate;

forming an electric connection pattern over one of the driving thin film transistor and the organic electroluminescent diode; and

attaching the first and second substrates such that the electric connection pattern electrically connects the driving thin film transistor and the organic electroluminescent diode.

29. The method according to claim 28, wherein forming the driving thin film transistor comprises:

forming a driving gate electrode including at least two-half ring shapes having at least two concave portions;

forming a driving semiconductor layer over the driving gate electrode; and

forming a driving source electrode, at least two driving drain electrodes on the driving semiconductor layer, the driving source electrode having at least two-half ring shape and overlapping an outer edge portion of the driving gate electrode, each of the at least two driving drain electrodes having a half circular shape in the at least two concave portions and overlapping an inner edge portion of the driving gate electrode.

30. The method according to claim 28, wherein forming the electric connection pattern comprises:

forming a passivation layer covering the driving thin film transistor, the passivation layer having a drain contact hole exposing a portion of the driving drain electrode;

forming a protrusive pattern on the passivation layer over the driving drain electrode; and

forming a connection electrode wrapping the protrusive pattern and connected to the driving drain electrode through the drain contact hole.

31. The method according to claim 30, wherein the drain contact hole includes first and second contact holes at both sides of the protrusive pattern.

32. The method according to claim 28, wherein forming an organic electroluminescent diode comprises:

forming a first electrode on the second substrate;

forming a separator having a tapered shape on the first electrode; and

forming an organic luminescent layer and a second electrode sequentially on the first electrode.

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专利名称(译)	双面板型有机电致发光器件及其制造方法		
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当前申请(专利权)人(译)	LG DISPLAY CO. , LTD.		
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摘要(译)

一种有机电致发光器件，包括彼此面对并彼此间隔开的第一和第二基板；第一基板内表面上的栅极线；数据线和与栅极线交叉并且彼此间隔开的电源线；开关薄膜晶体管，连接到栅极线和数据线；驱动薄膜晶体管，连接到开关薄膜晶体管和电源线，驱动薄膜晶体管包括具有环形的沟道区；连接到驱动薄膜晶体管的电连接图案，连接图案设置在驱动薄膜晶体管上；在第二基板的内表面上的有机电致发光二极管，有机电致发光二极管连接到电连接图案。

